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UV and IR generation in silica-based optical fibres and tapers

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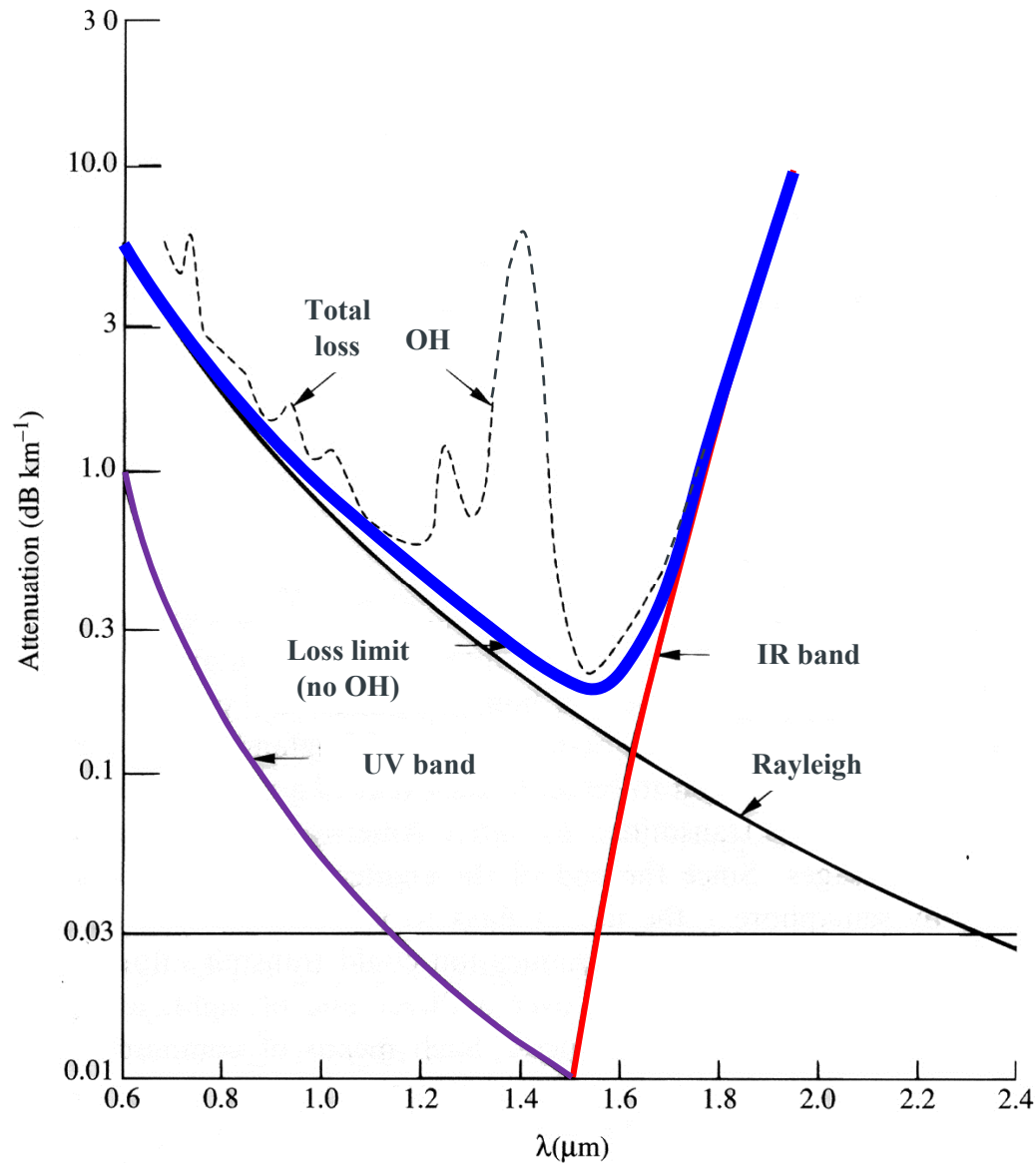
Singapore, 1 July 2013



Outline

- Introduction
- χ^3 nonlinear process
- UV generation (THG)
- IR generation (TPG)
- Conclusion

Introduction: optical fibre loss



Introduction

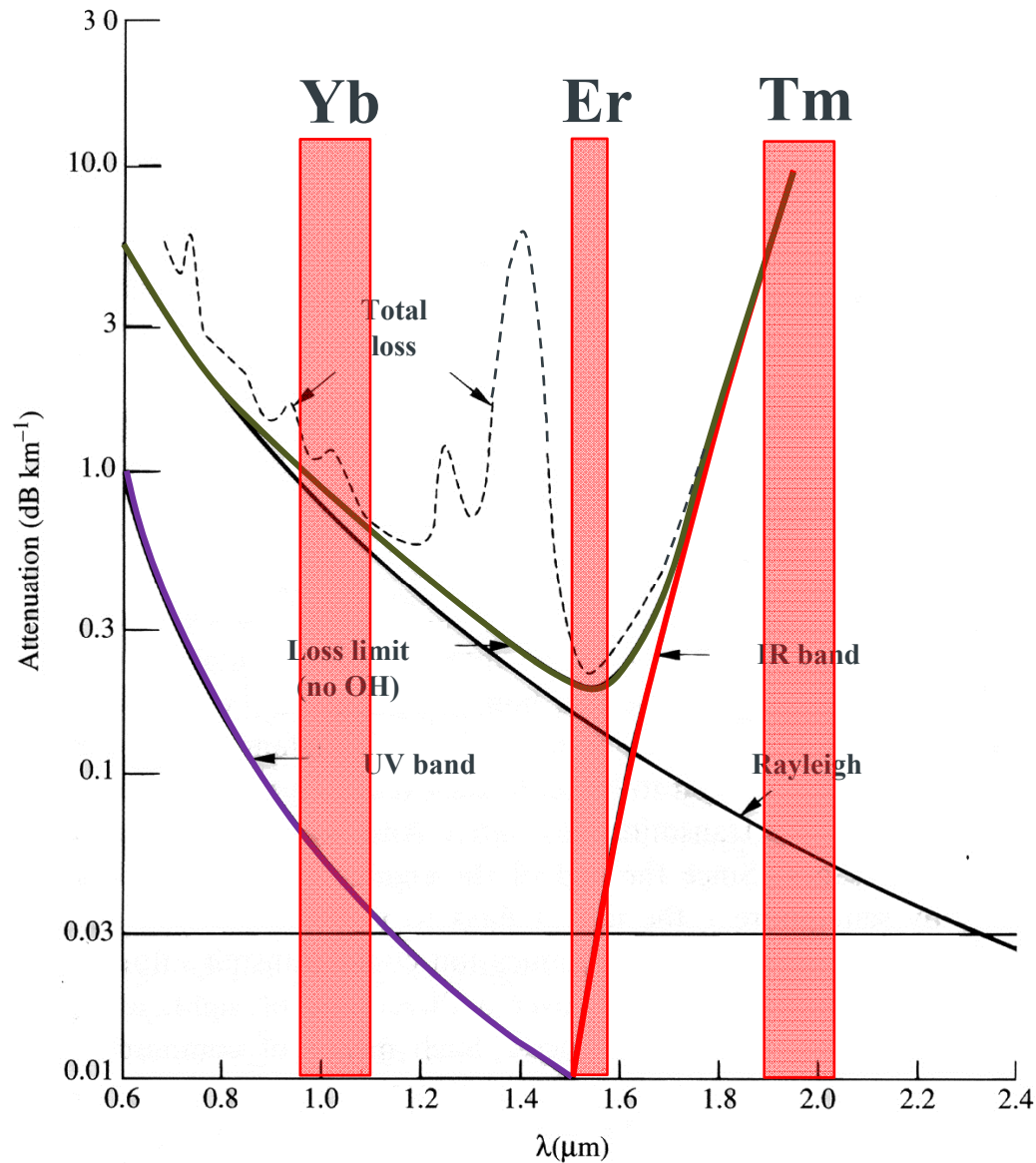
Nonlinear
processes

UV generation

IR generation

Conclusions

Optical fibre lasers



Introduction
Fibre lasers

Nonlinear
processes

UV generation

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Introduction: optical fibre laser

Advantages include:

- Efficient cooling: high surface to volume ratio
- Thus, no thermal lensing and high-quality optical beam: $M^2 \sim 1$
- High brightness
- High output power: active regions m long, thus very high optical gain
- Compact, reliable
- Light is already coupled into a flexible fibre

Introduction
Fibre lasers

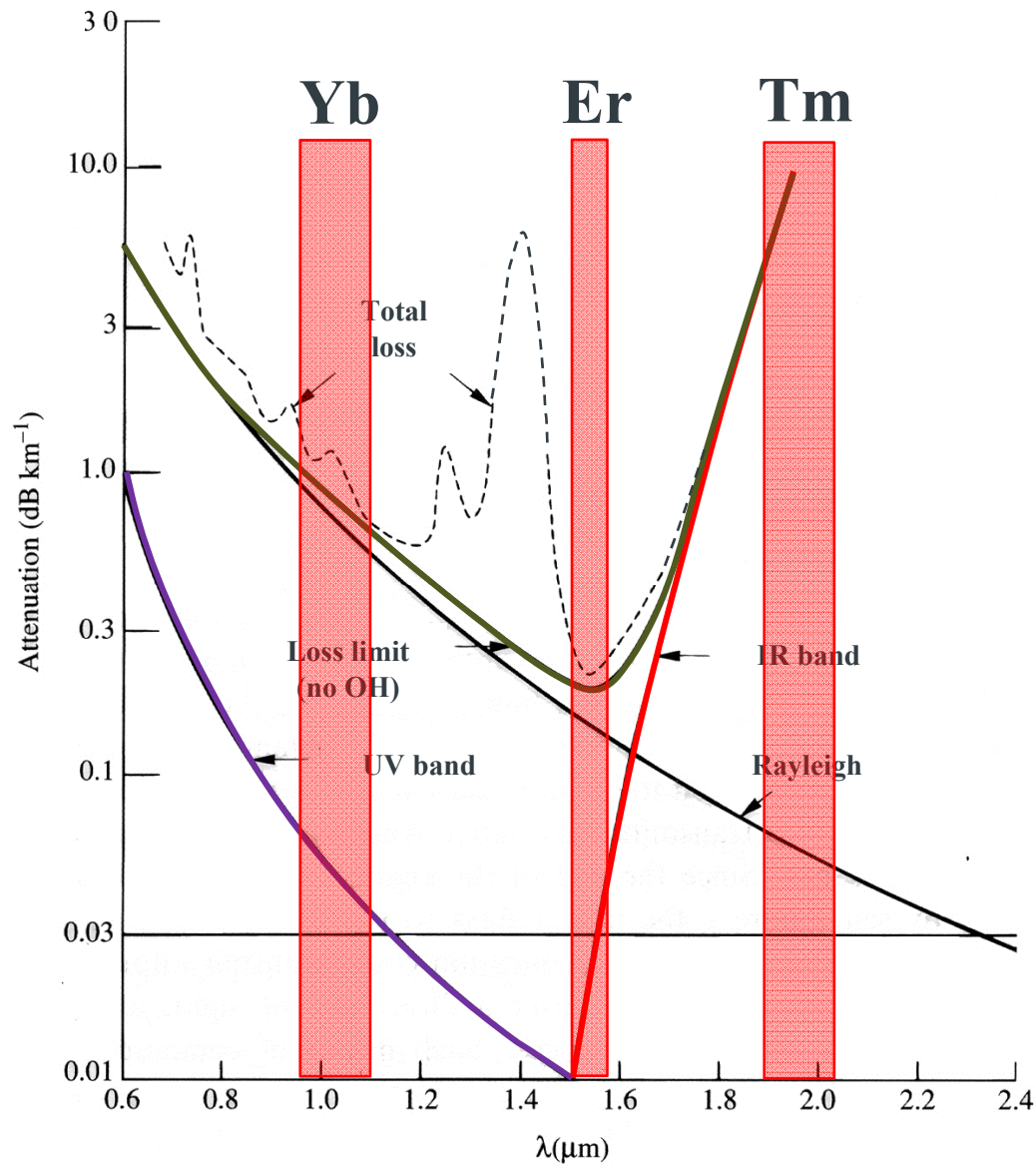
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Introduction
Fibre lasers

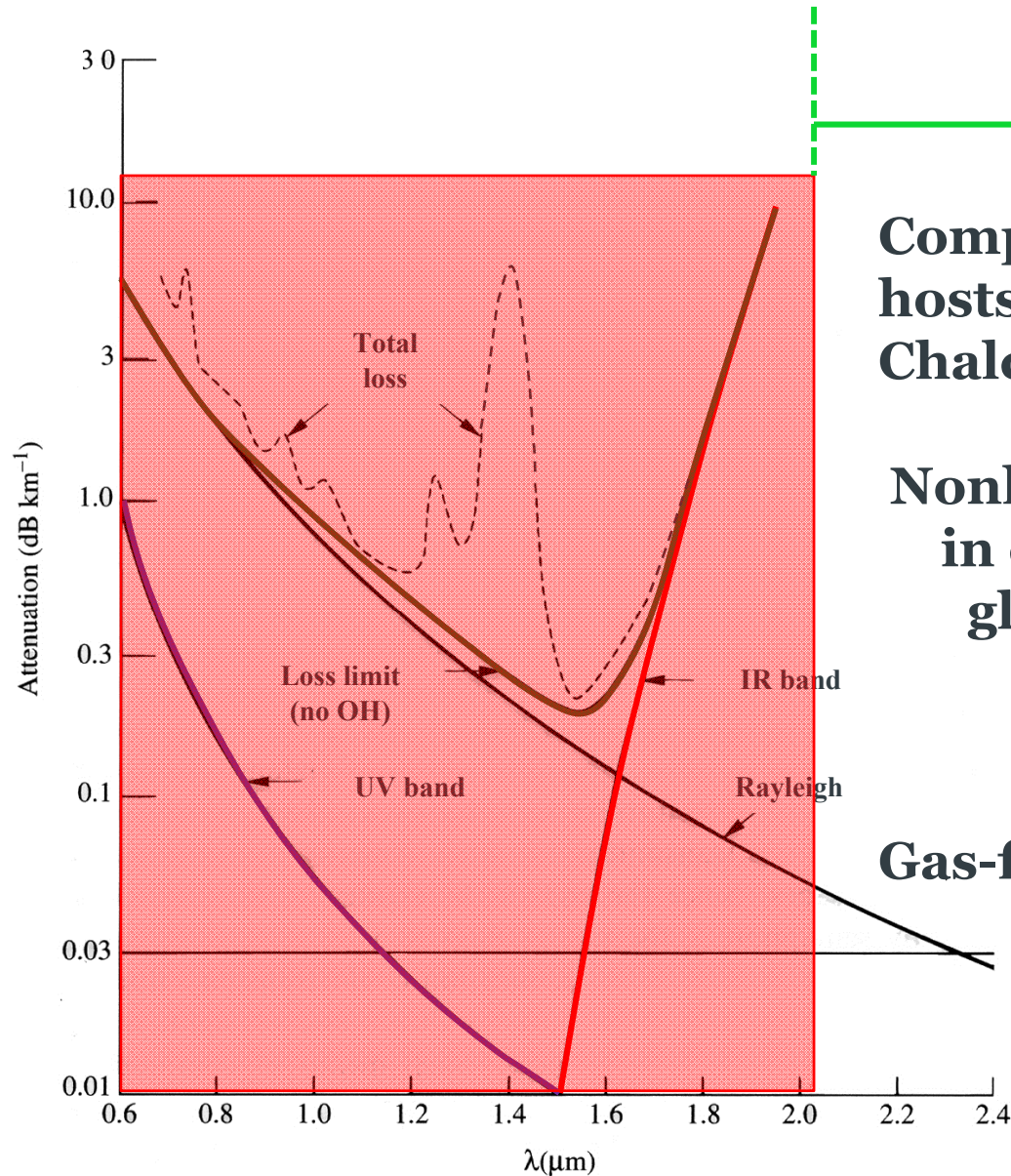
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Optical fibre lasers



**Compound glass
hosts: ZBLAN,
Chalcogenides**

**Nonlinear Optics
in compound
glass fibres**

OR

Gas-filled PBGF

Introduction
Fibre lasers

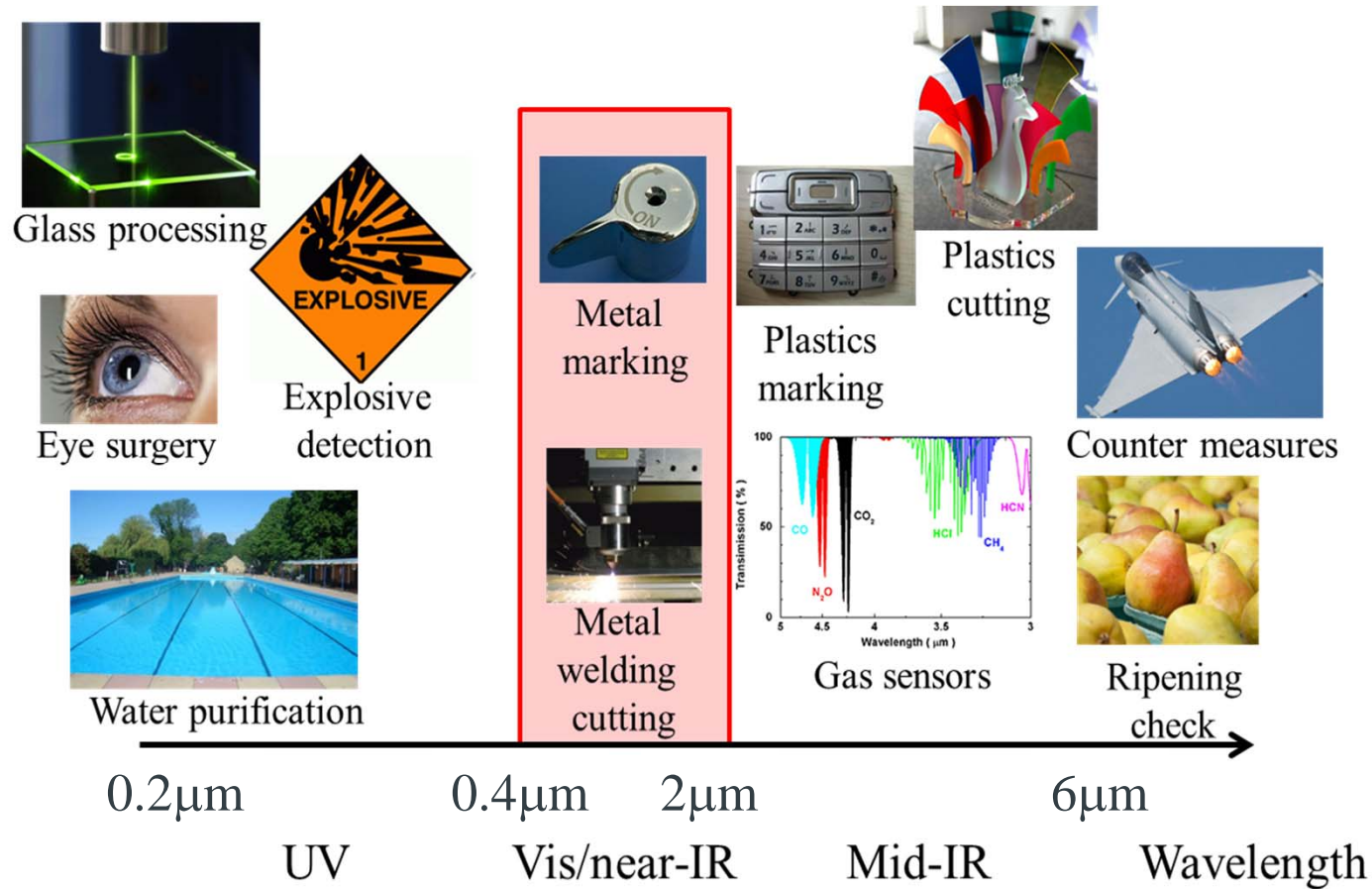
Nonlinear
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Laser applications



Introduction Applications

Nonlinear
processes

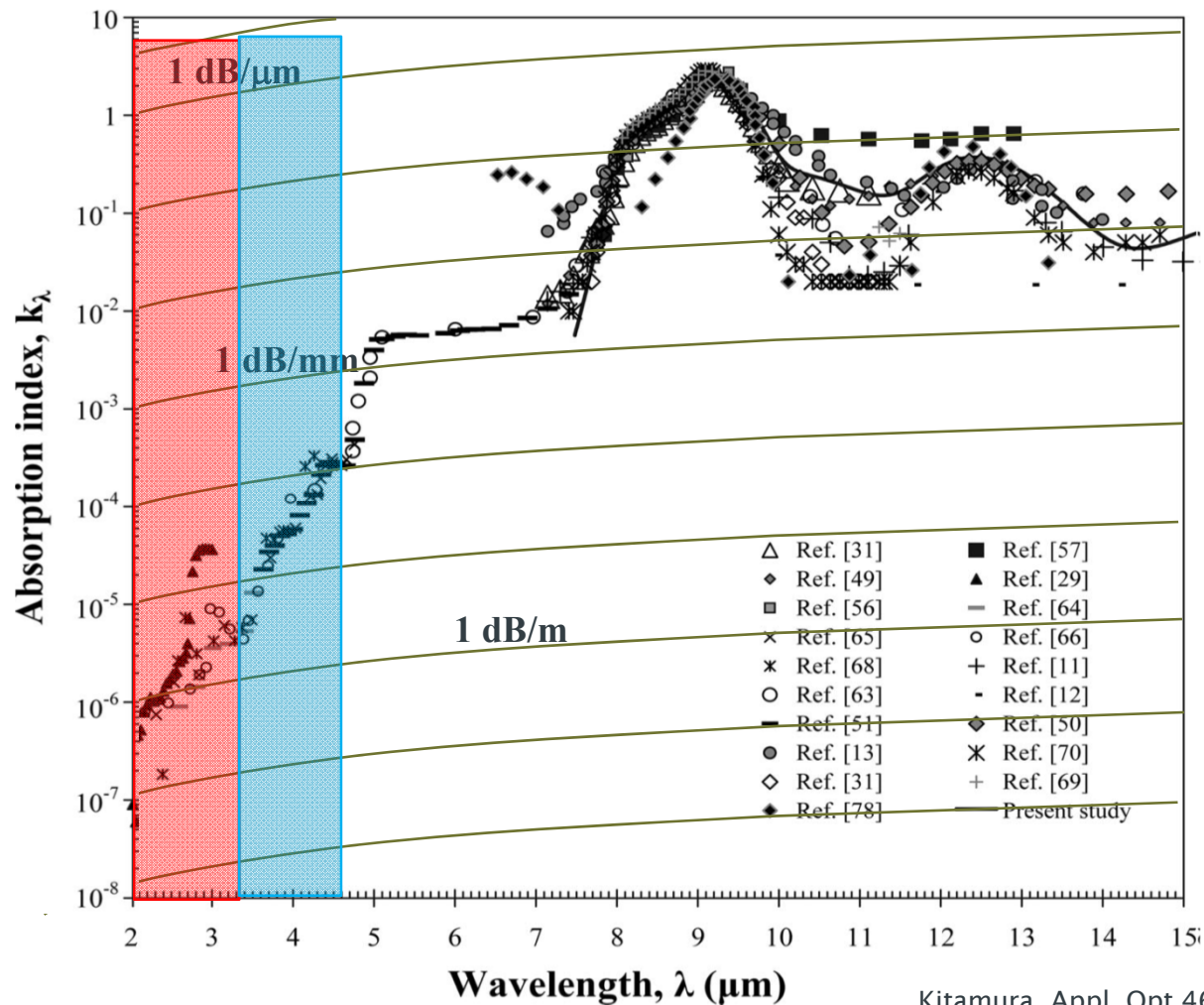
UV generation

IR generation

Conclusions

Silica loss: long λ

3 dB/m **1 dB/cm**
Active **Nonlinear**
fibres **processes**



Kitamura, Appl. Opt 46(33),8118, 2007.

Introduction
Silica loss

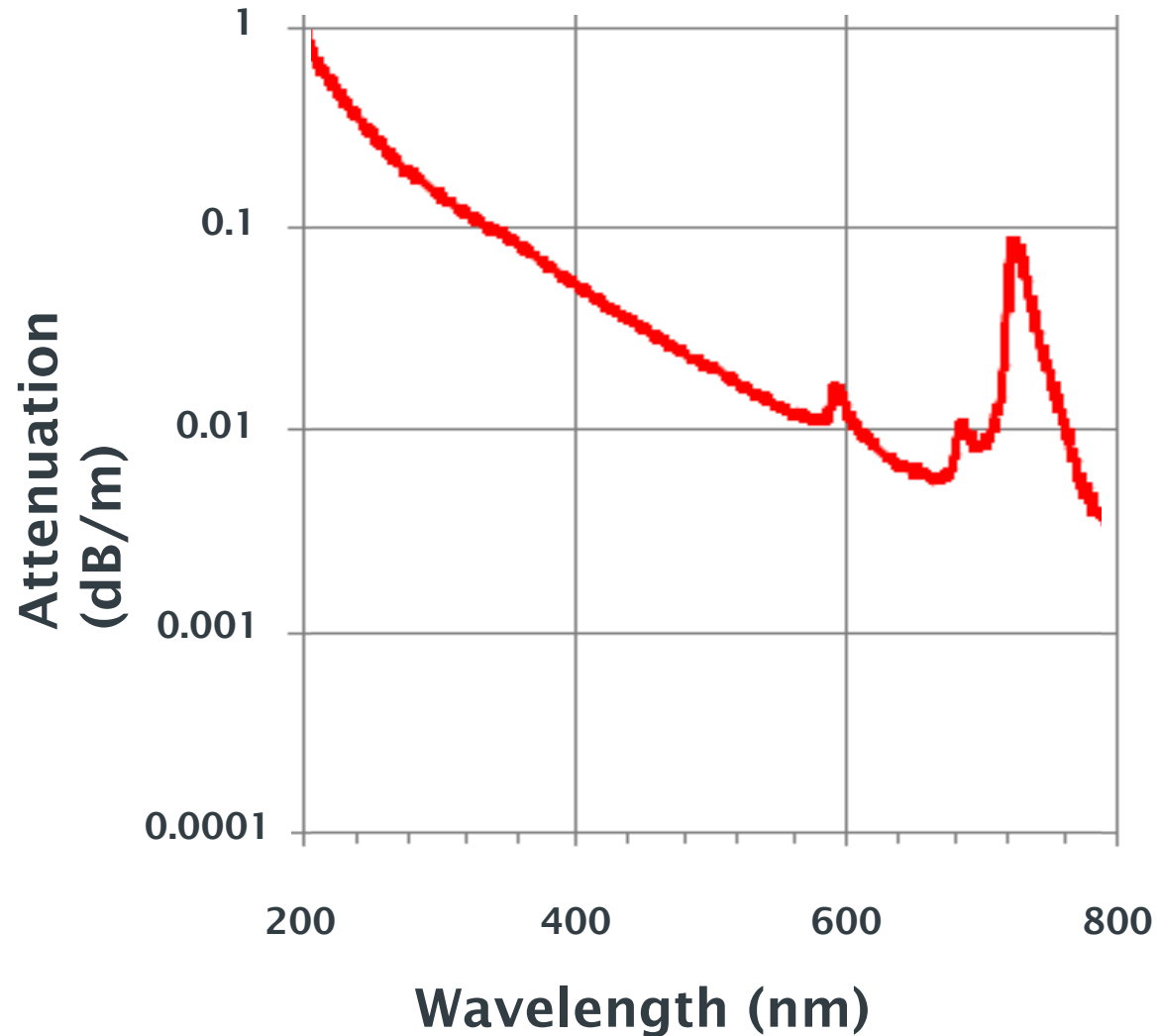
Nonlinear
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Silica loss: short λ



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Nonlinear processes

Requirements:

- **Efficient (few cm of fibre at most)**
- **Pump must be in low loss wavelength region (500nm-2 μ m)**
- **Compatible with fibre material (glass)**
(no $\chi^{(2)}$).
- **Compatible with fibre geometry**

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Nonlinear processes: UV

Third Harmonic Generation



- It uses $\chi^{(3)}$
- Pump is in the low loss wavelength region (500nm-2 μ m)
- Compatible with glass and fibre geometry.

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**Nonlinear
processes**

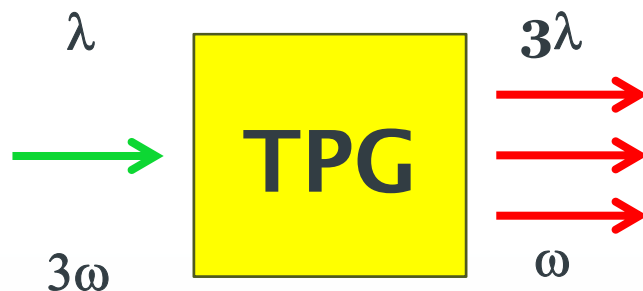
UV generation

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Nonlinear processes: IR

Three Photon Generation



- It uses $\chi^{(3)}$
- Pump is in the low loss wavelength region (500nm-2 μ m)
- Compatible with glass and fibre geometry.

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THG - TPG

Third Harmonic / Three photon Generation

- **Phase matching**

$$\Delta\beta = \beta(3\omega) - 3\beta(\omega) \approx 0,$$

- **High overlap between pump and third harmonic mode**

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Third Harmonic Generation Phase matching

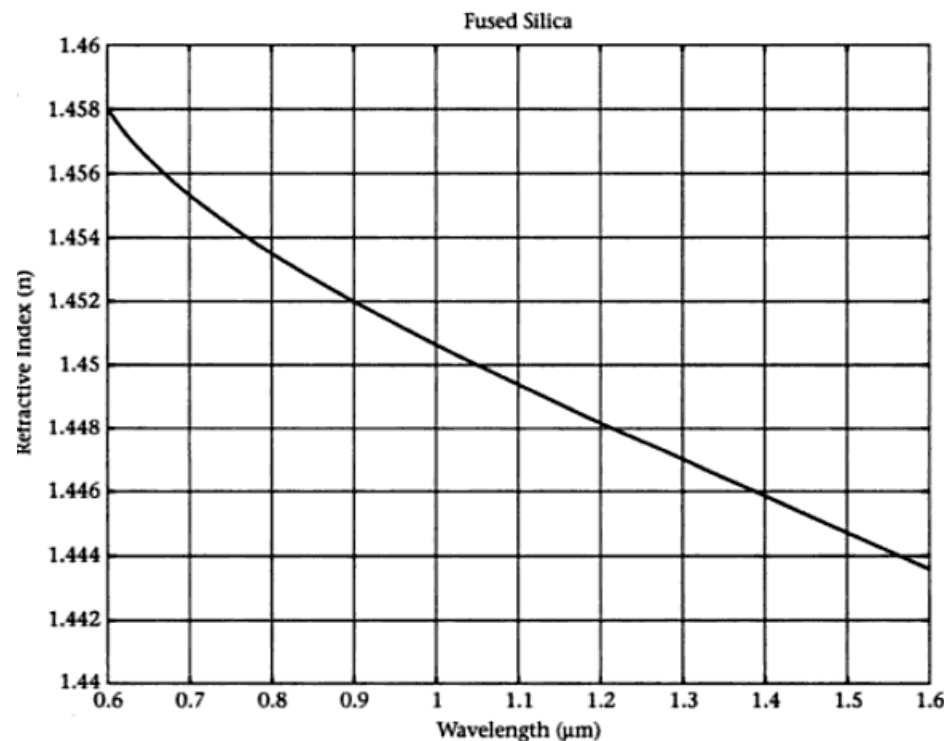
Third harmonic generation is efficient if

$$\beta(\omega) = \beta(3\omega)$$

$$\beta = n_{\text{eff}} (2\pi/\lambda)$$

$$n_{\text{eff}} = \frac{\int_0^{2\pi} \int_0^\infty n(r, \vartheta) I(r, \vartheta) dr d\vartheta}{\int_0^{2\pi} \int_0^\infty I(r, \vartheta) dr d\vartheta}$$

refractive index
 mode intensity distribution
 radial coordinate
 azimuthal coordinate



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Phase matching

n_{eff} depends

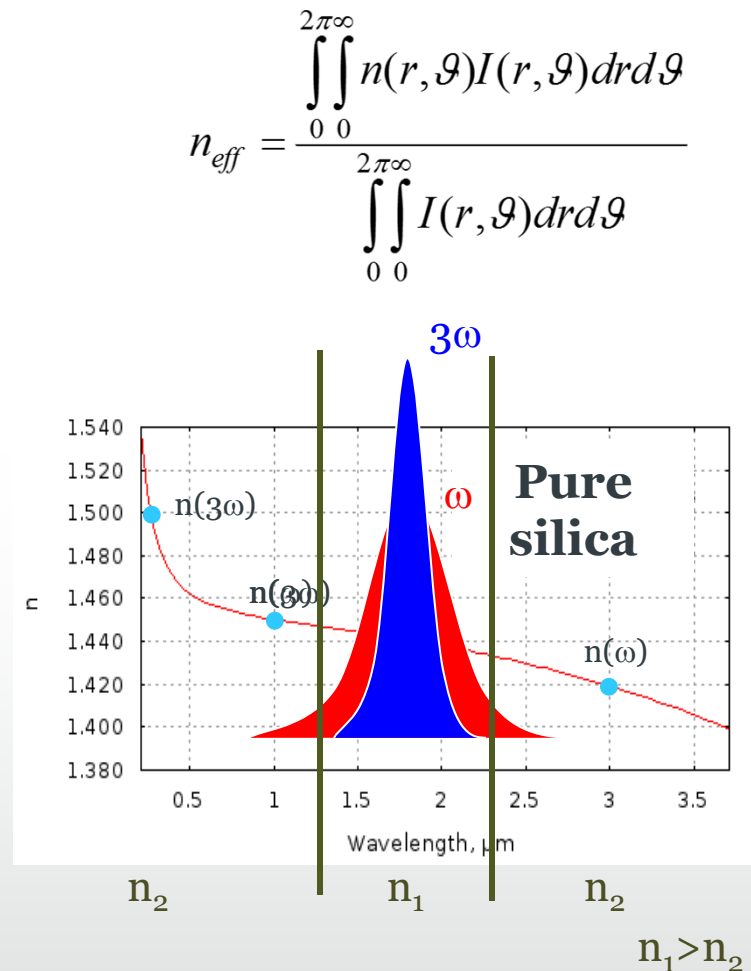
- Material dispersion

$$n_{\text{eff}}(3\omega) \gg n_{\text{eff}}(\omega)$$

- Mode confinement
for fundamental mode

$$n_{\text{eff}}(3\omega) \gg n_{\text{eff}}(\omega)$$

BUT n_{eff} decreases for mode order



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Silica loss

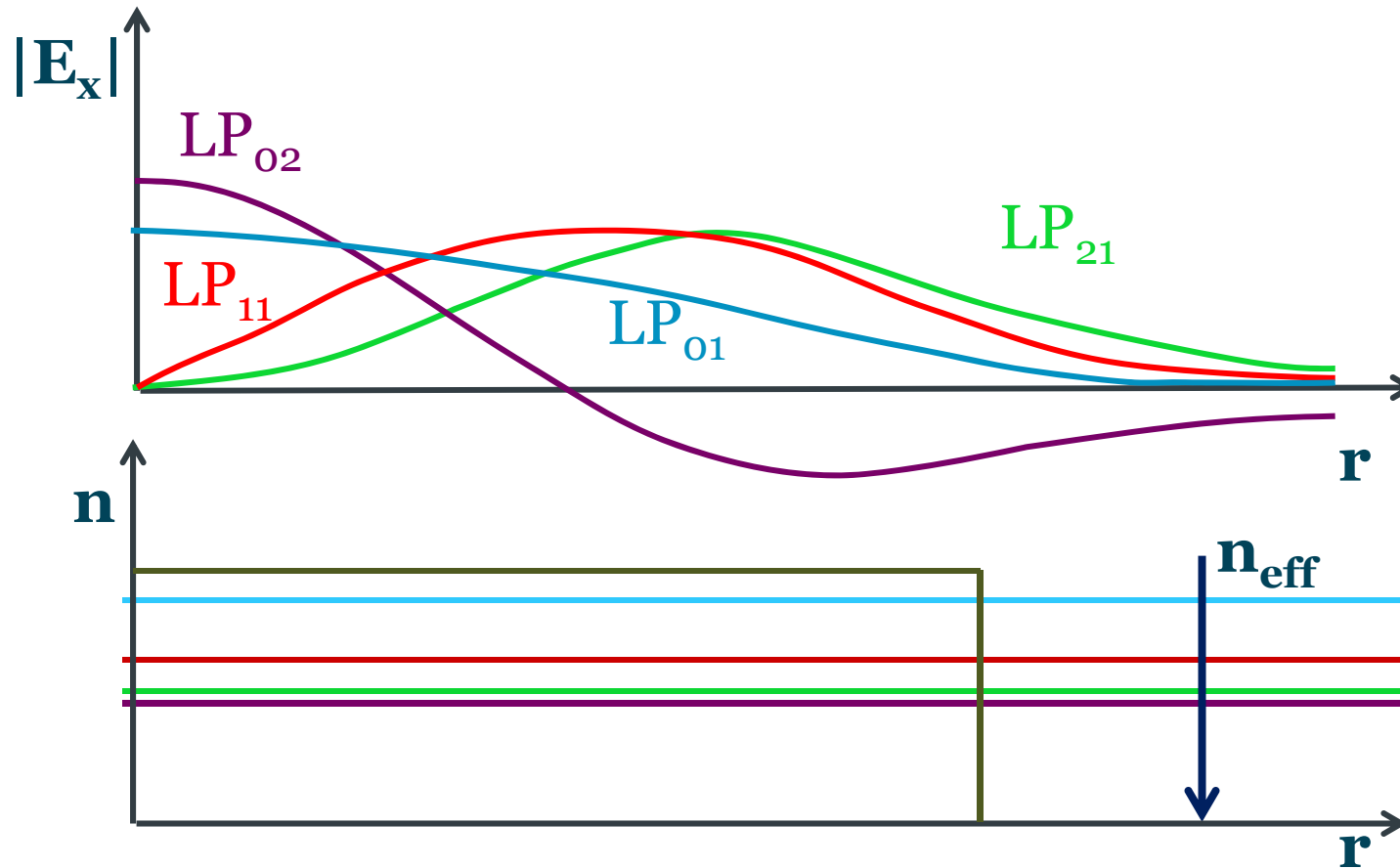
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THG: high order mode n_{eff}



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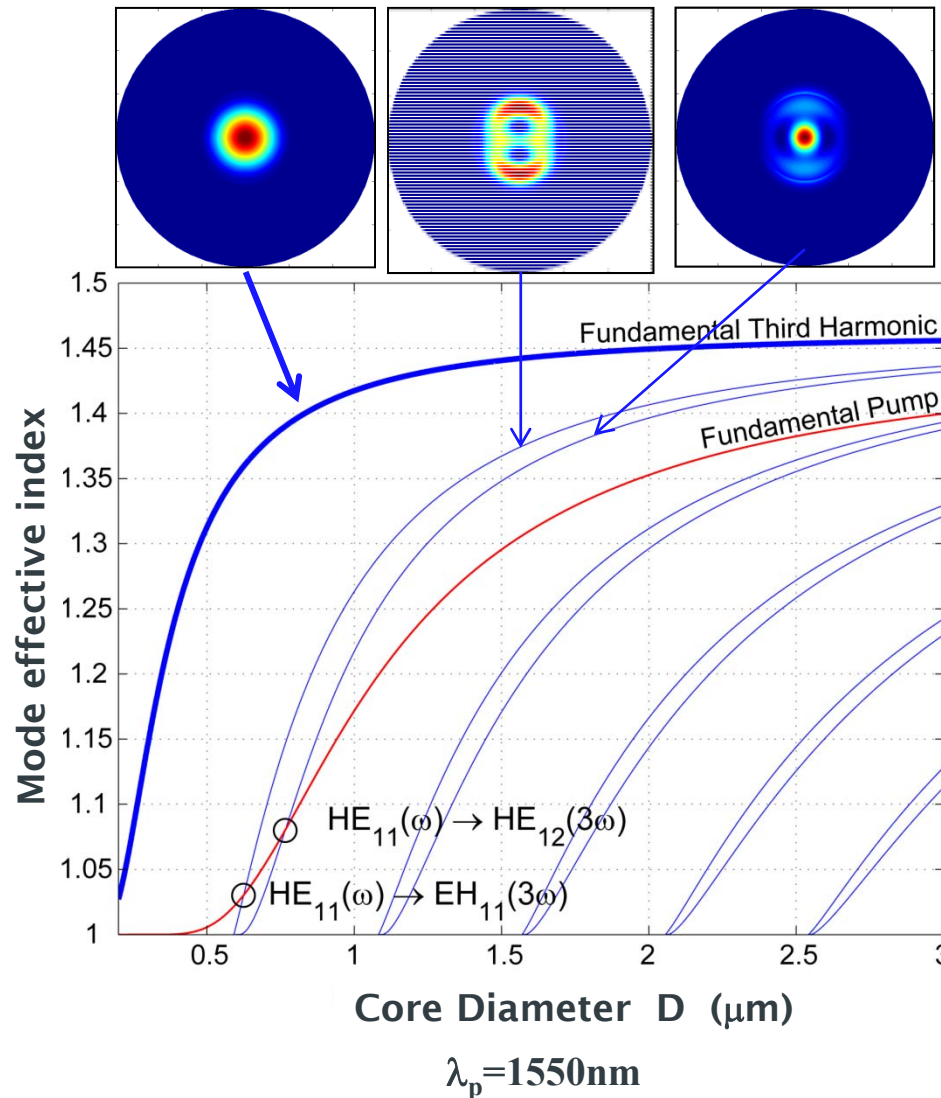
Conclusions

High order modes extend further in the low n medium
they have a lower n_{eff} .

intermodal phase matching

Phase matching

- Fundamental $HE_{11}(\omega)$ pump mode can be phase matched only to higher order third harmonic modes.
- For pump λ_p , critical diameters exist at $\sim \lambda_p/2$ for $NA \sim 1$.



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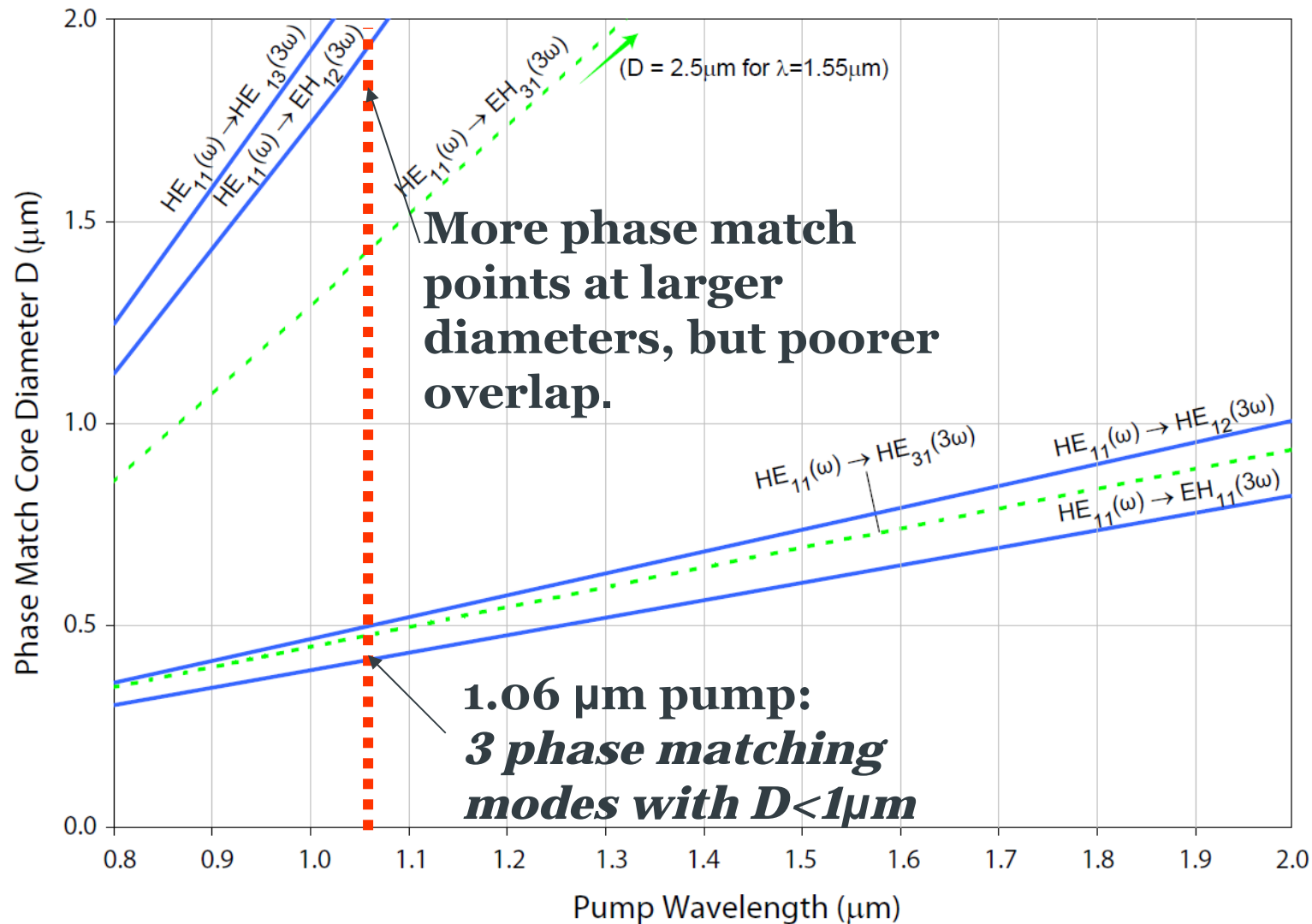
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Phase matching



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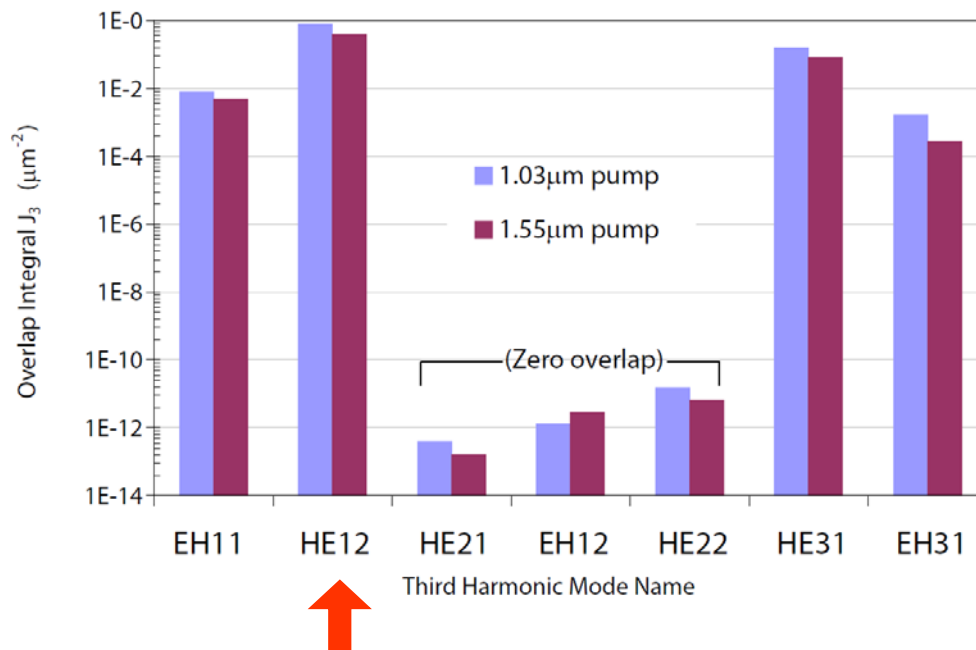
UV generation

IR generation

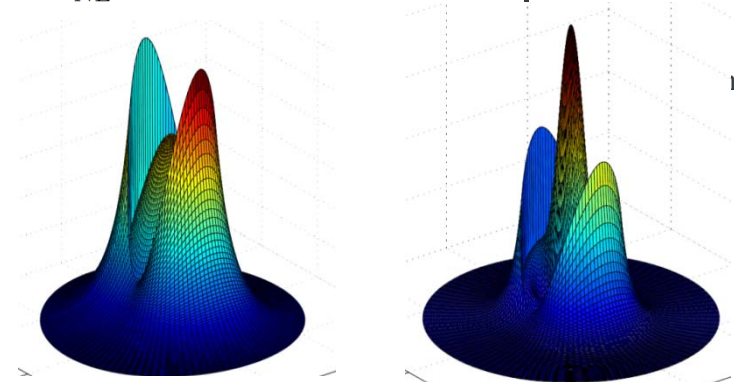
Conclusions

THG: Overlap

- Overlap between pump and TH mode governs efficiency.
- $HE_{12}(3\omega)$ overlap is greatest: $0.76 \mu\text{m}^{-2}$ for a $1.0 \mu\text{m}$ pump
- It increases for decreasing wavelengths (it is $0.38 \mu\text{m}^{-2}$ for $1.55 \mu\text{m}$ pump).
- Overlap is zero TE , TM and hybrid HE_{vm} EH_{vm} modes with even azimuthal mode order number v .



$$J_3 = \iint_{A_{NL}} \left((\mathbf{F}_1 \cdot \mathbf{F}_3) |\mathbf{F}_1^*|^2 \right) dA$$



Pump
 $HE_{11}(\omega)$

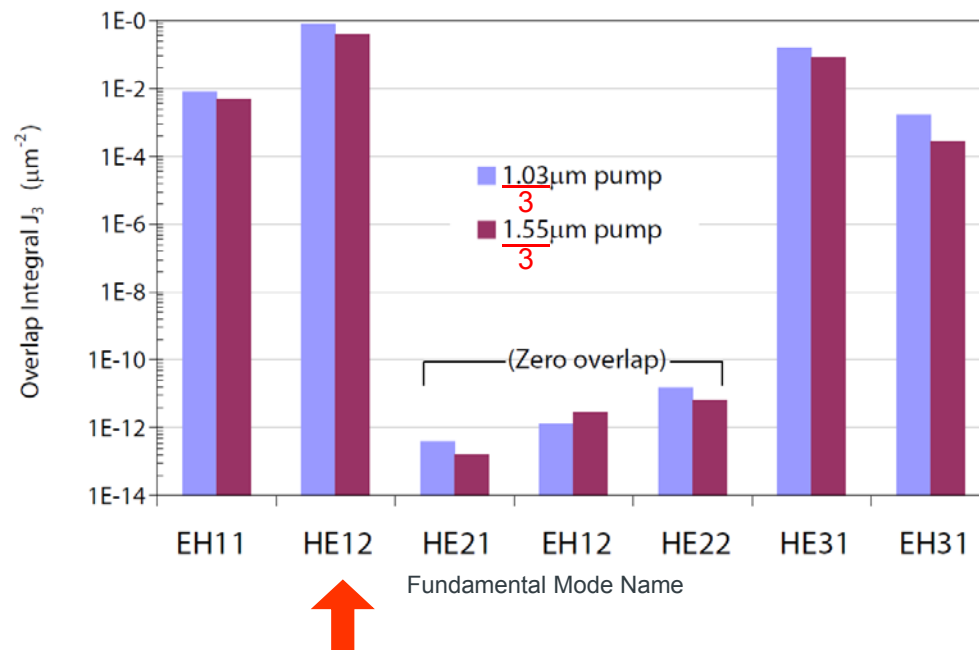
Third Harmonic
 $HE_{12}(3\omega)$

Introduction
Silica loss

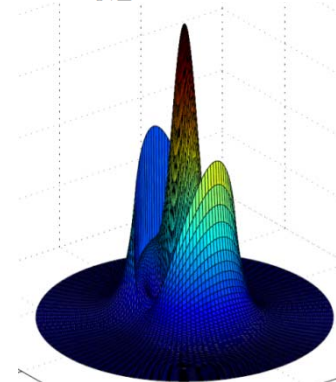
Nonlinear
processes

TPG: Overlap

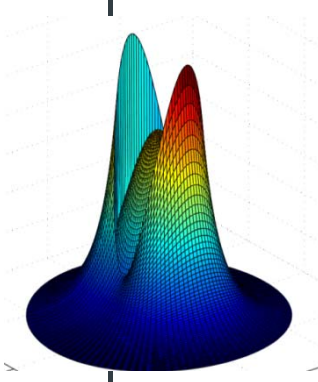
- Overlap between pump and TP mode governs efficiency.
- $HE_{12}(\lambda)$ overlap is greatest.
- Pump is in high order mode!



$$J_3 = \iint_{A_{NL}} \left((F_1 \cdot F_3) |F_1^*|^2 \right) dA$$



Pump
 $HE_{12}(\lambda)$



Three photons
 $HE_{11}(3\lambda)$

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THG: experiment

Taper

$D = 0.78 \mu\text{m}$,

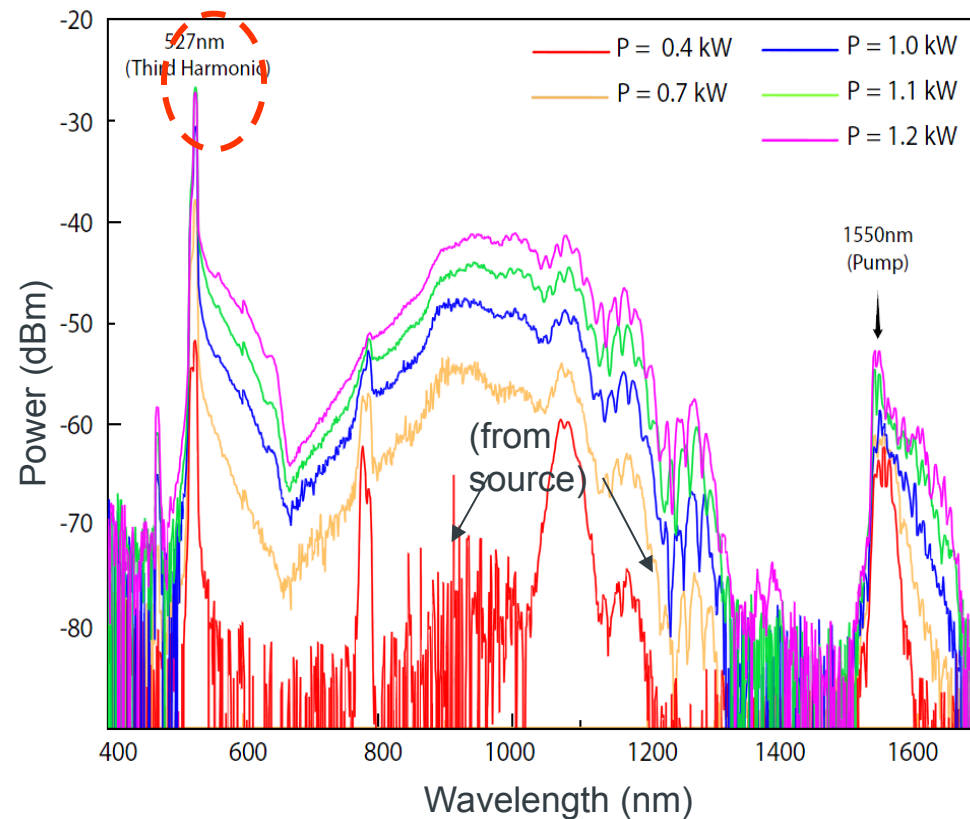
$L \sim 200 \mu\text{m}$

- Diameter is closer to critical value.
- Peak at 527nm
- asymmetric TH spectrum.

$$\eta_{\text{meas}} \sim 10^{-3}$$

$$\eta_{\text{th}} = 2 \cdot 10^{-2}$$

Spectrum recorded after
shortpass filter:



Introduction
Silica loss

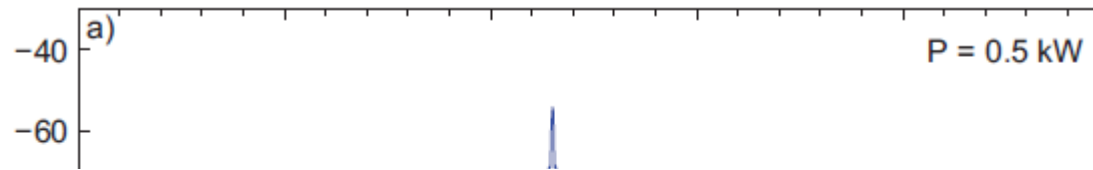
**Nonlinear
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UV generation

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THG: broadband generation



Broadband third harmonic generation in tapered silica fibres

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²SPI Lasers, Southampton, SO30 2QU, United Kingdom

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Abstract: Optical microfibres have recently attracted much attention for nonlinear applications, due to their tight modal confinement. Here, we report broadband third harmonic generation based on the intermodal phase matching technique in silica microfibres of several centimetres. The third harmonic signal is predominantly generated from the taper transition regions (rather than the waist), wherein the range of diameters permits phase matching over a wide bandwidth. Microfibres up to 4.5 cm long were fabricated with waist diameters below $2.5\ \mu\text{m}$ to allow a $\lambda = 1.55\ \mu\text{m}$ pump to phase match with several higher order third harmonic modes; conversion rates up to 3×10^{-4} were recorded when pumped with 4 ns pulses at a peak power of 1.25 kW. Analysis of the third harmonic frequencies generated from the nonlinearly broadened pump components indicate a 5 dB conversion bandwidth of at least 36 nm, with harmonic power detected over a 150 nm range.

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OCIS codes: (190.0190) Nonlinear optics; (190.2620) Harmonic generation and mixing; (190.4160) Multiharmonic generation; (190.4370) Nonlinear optics, fibers.

Introduction
Silica loss

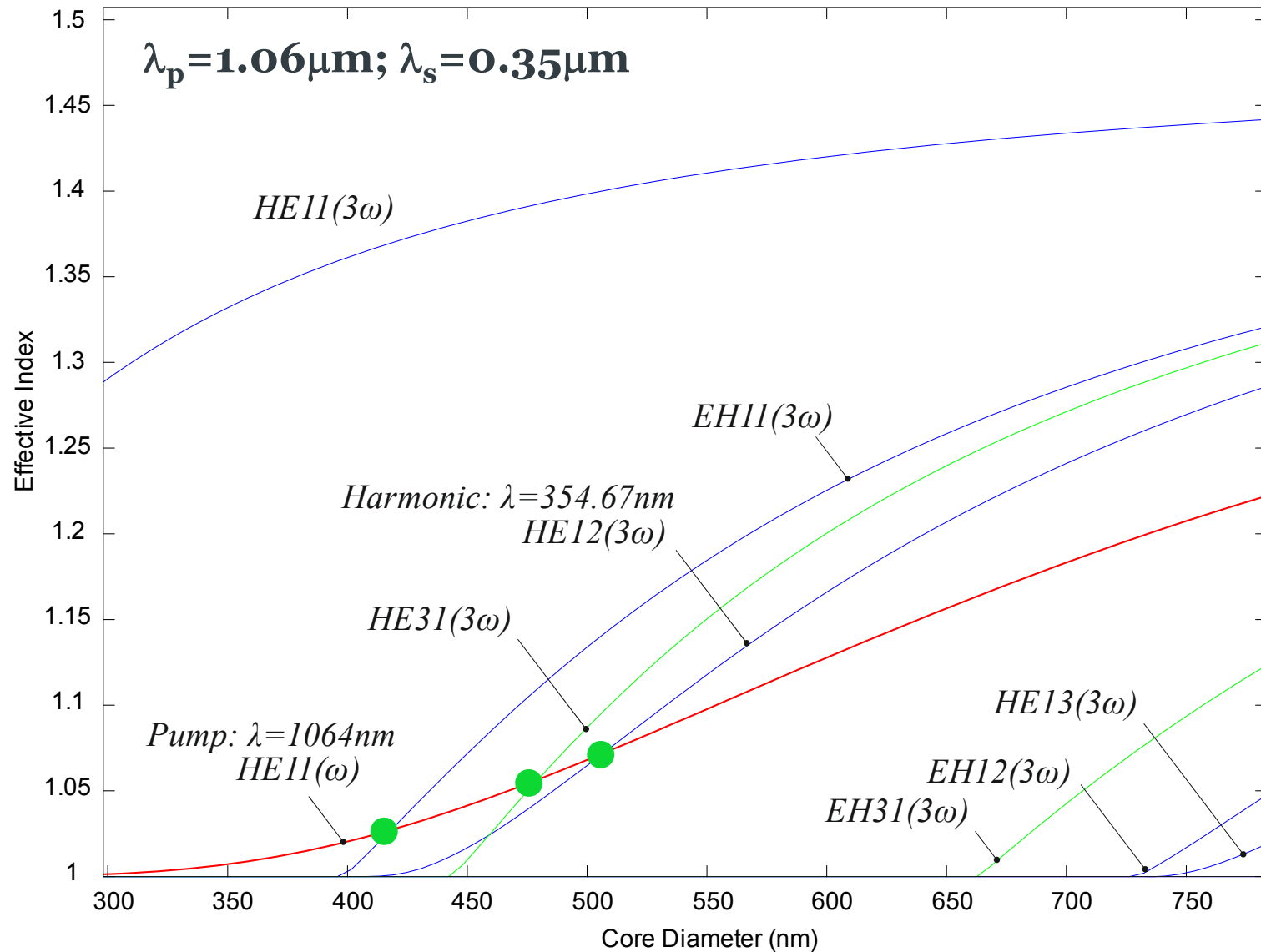
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UV: Phase matching at $\lambda=0.35\mu\text{m}$



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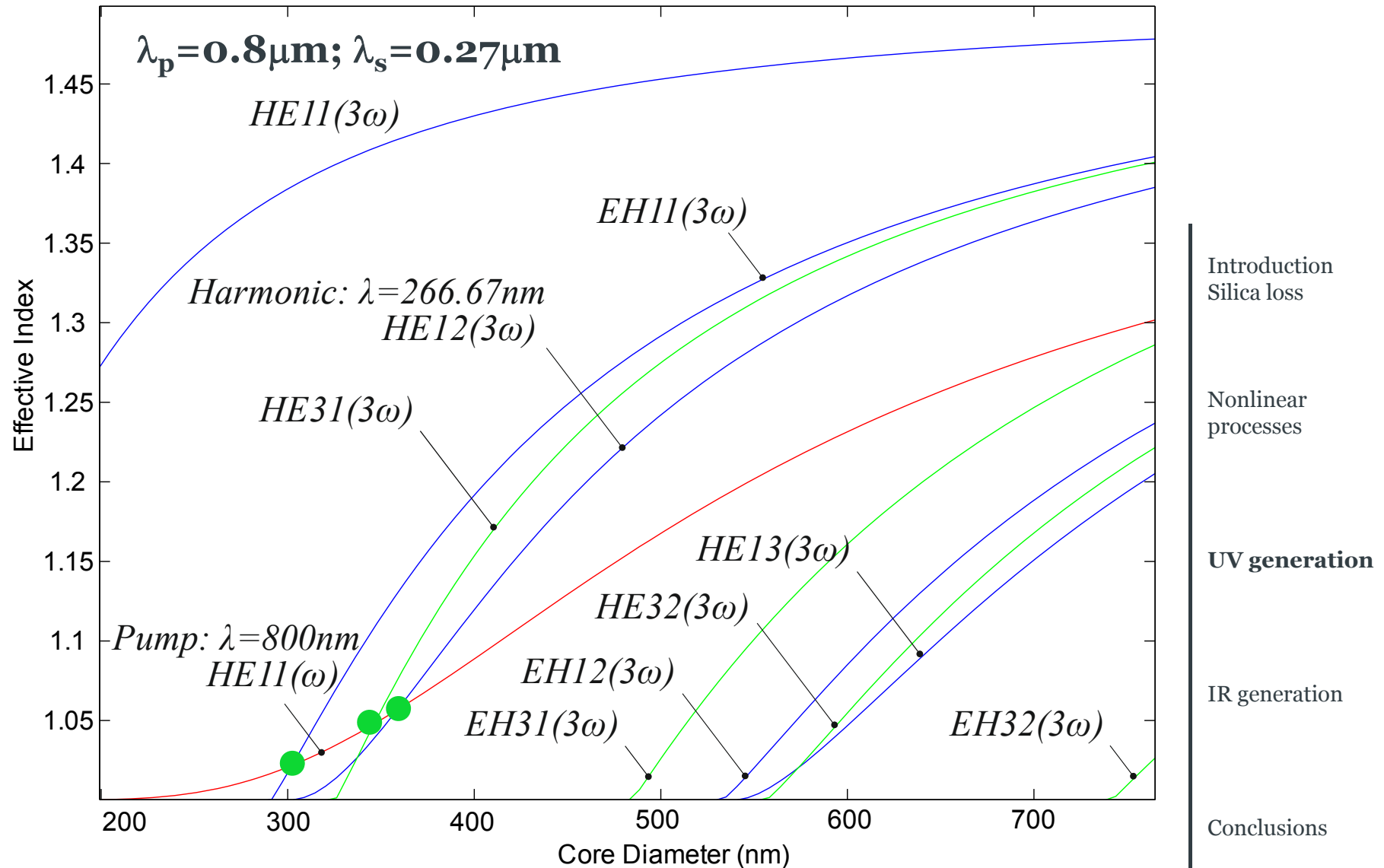
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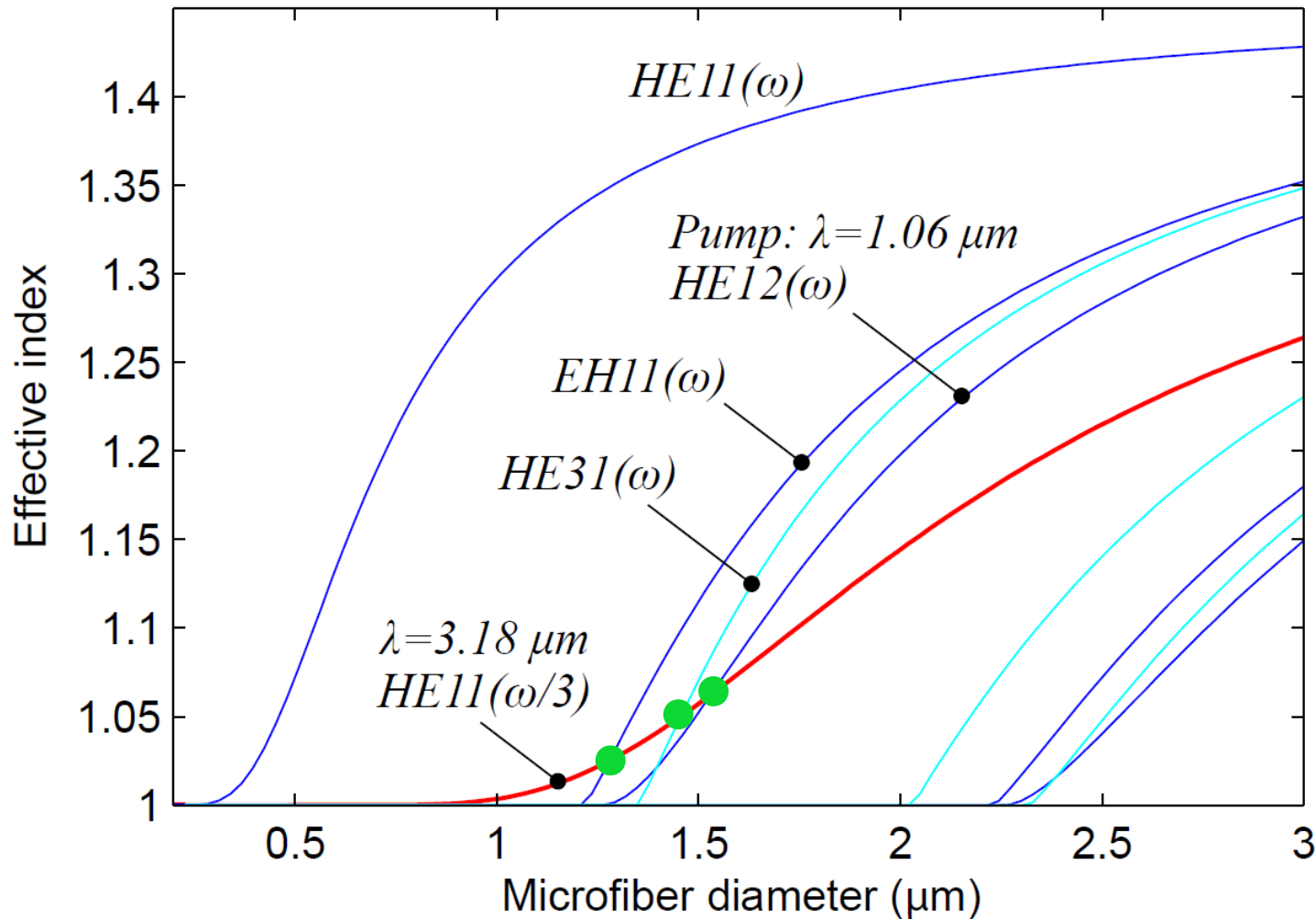
Conclusions

UV: Phase matching at $\lambda=0.27\mu\text{m}$



IR: Phase matching at $\lambda=3.18\mu\text{m}$

$$\lambda_p=1.06\mu\text{m}; \lambda_s=3.18\mu\text{m}$$



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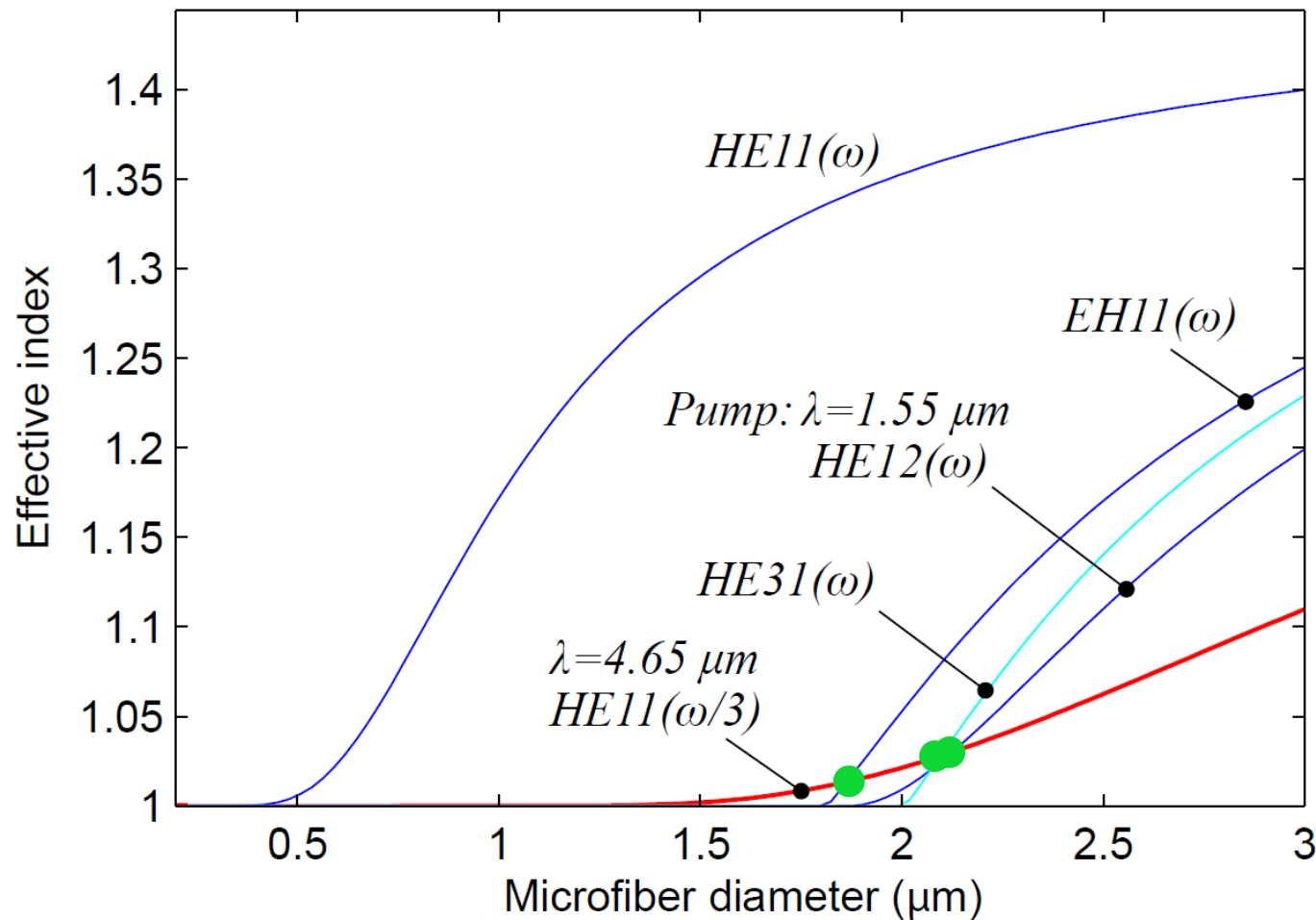
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IR: Phase matching at $\lambda=4.65\mu\text{m}$

$$\lambda_p=1.55\mu\text{m}; \lambda_s=4.65\mu\text{m}$$



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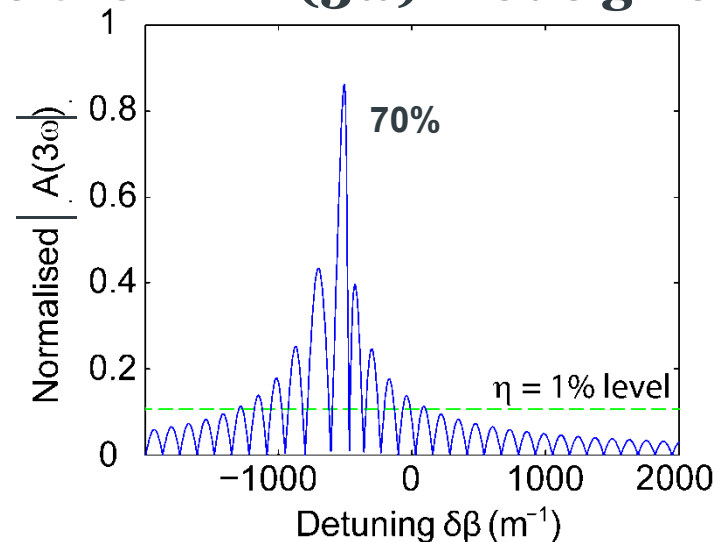
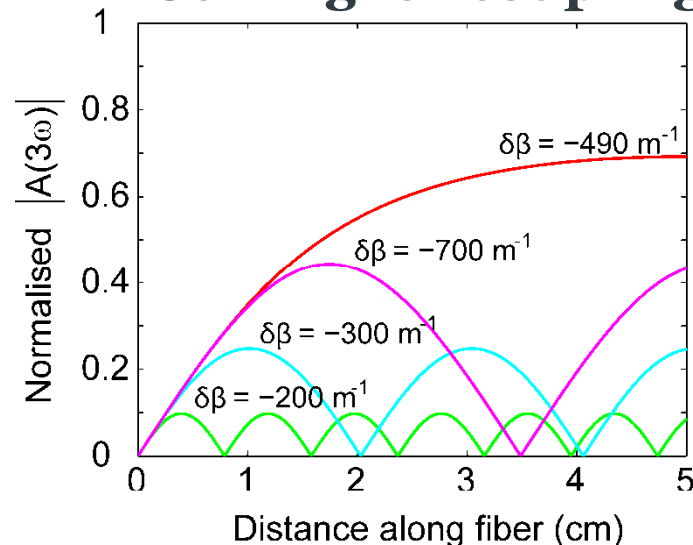
Conclusions

THG: conversion efficiency

- THG differential equations [1] :

	SPM	XPM	THG term with detuning
Pump:	$\frac{dA_1}{dz} = in^{(2)}k_1 \left\{ (J_1 A_1 ^2) + 2J_2 A_3 ^2 \right\} A_1 + J_3A_1^*A_3e^{i\delta\beta z}$		
Third Harmonic:		$\frac{dA_3}{dz} = in^{(2)}k_1 \left\{ (6J_2 A_1 ^2 + 3J_5 A_3 ^2) A_3 + J_3^*A_1^3e^{-i\delta\beta z} \right\}$	

- Solving for coupling to the HE₁₂(3 ω) mode gives:

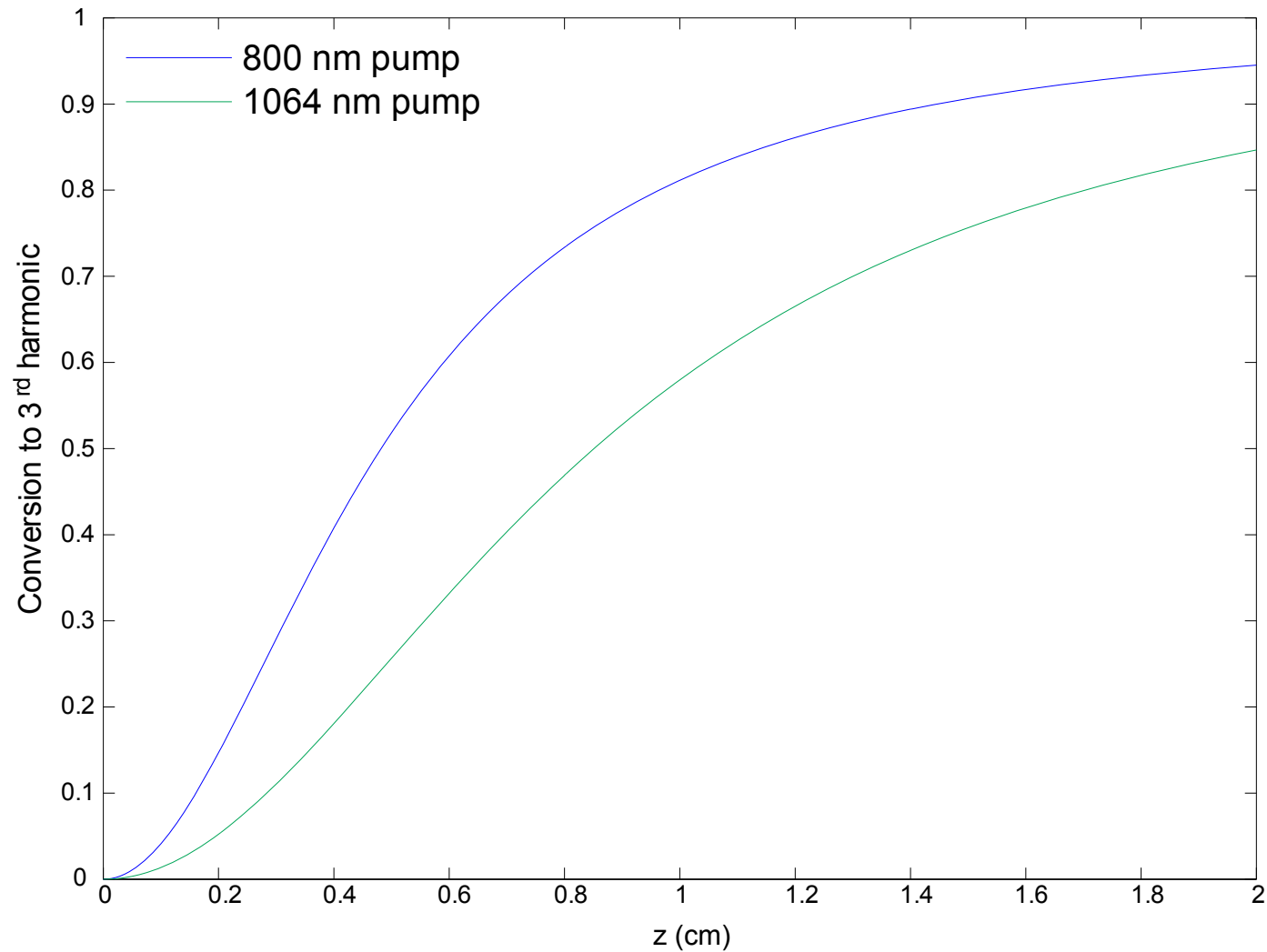


Parameters:

- Length 5cm
- Diameter $0.77\mu\text{m}$
- $P_{\text{in}} = 1\text{kW}$

[1] V. Grubsky and A. Savchenko, Opt. Expr. 13, 6798 (2006).

UV conversion efficiency



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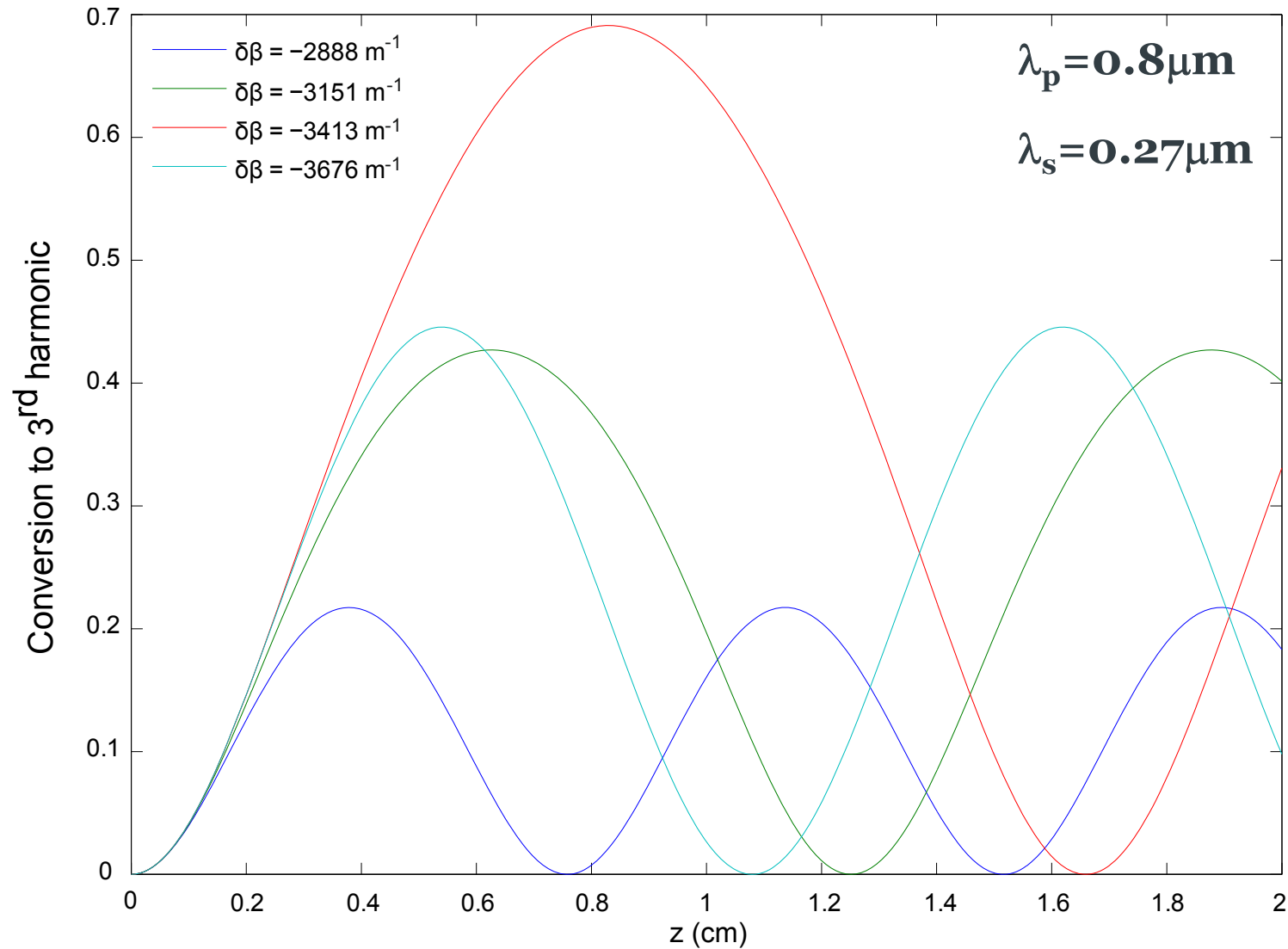
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THG: detuning



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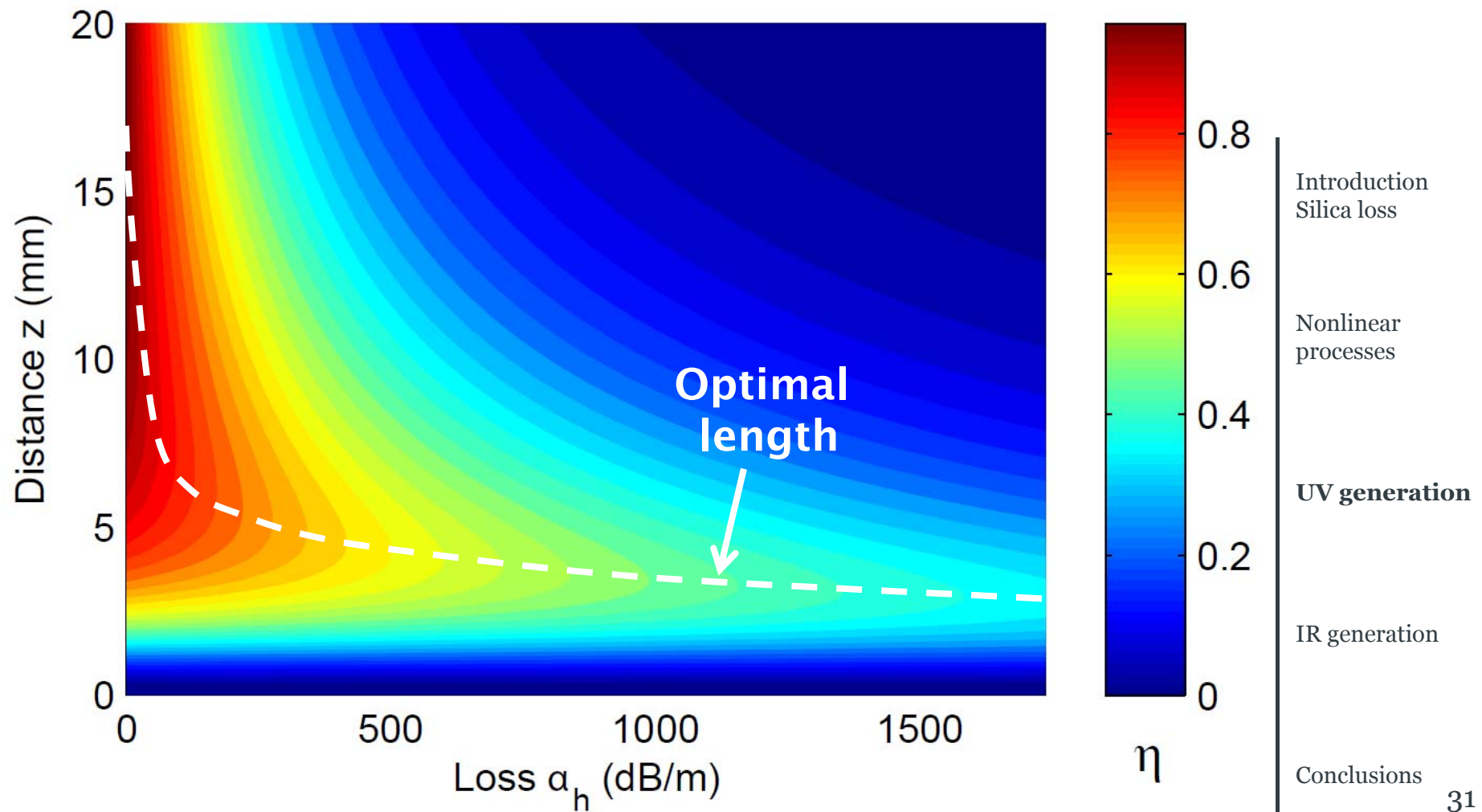
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THG: Effect of loss

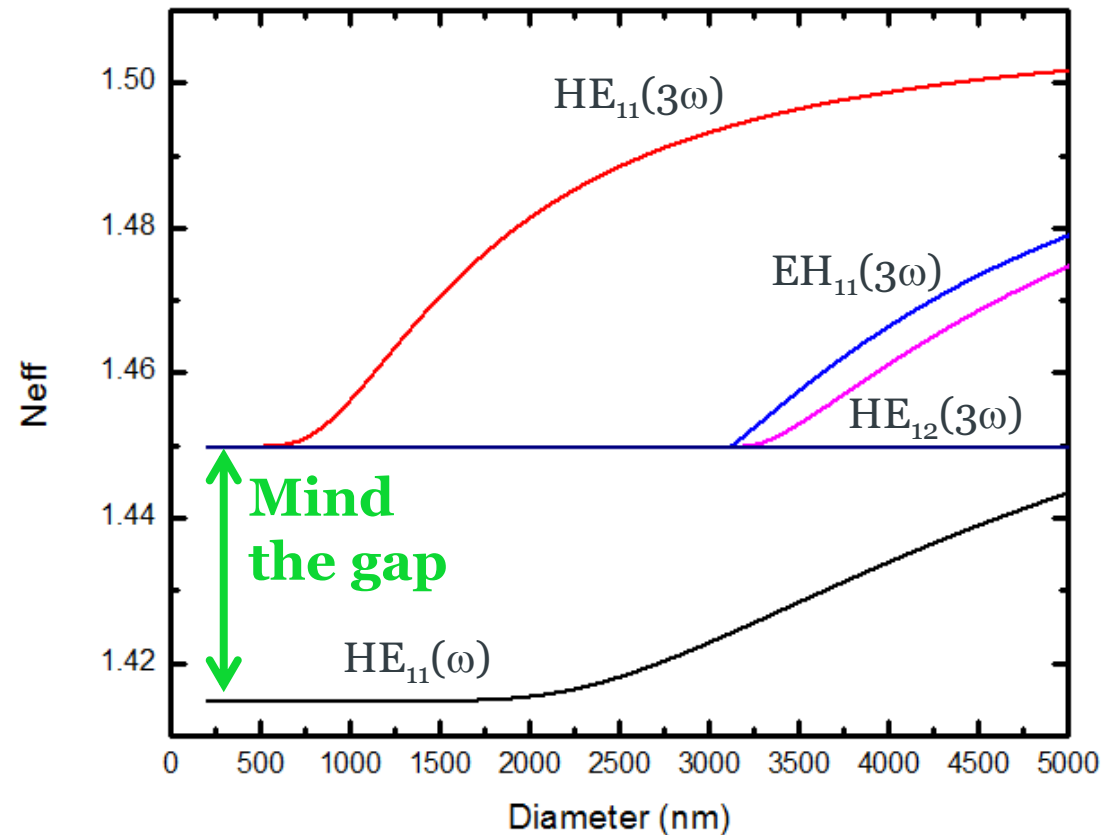


Fibres: Phase matching

$$\lambda_p = 1.06 \mu\text{m}; \lambda_s = 3.18 \mu\text{m}$$

Ge-doped silica fibre. [Ge]=40%

NA~0.42



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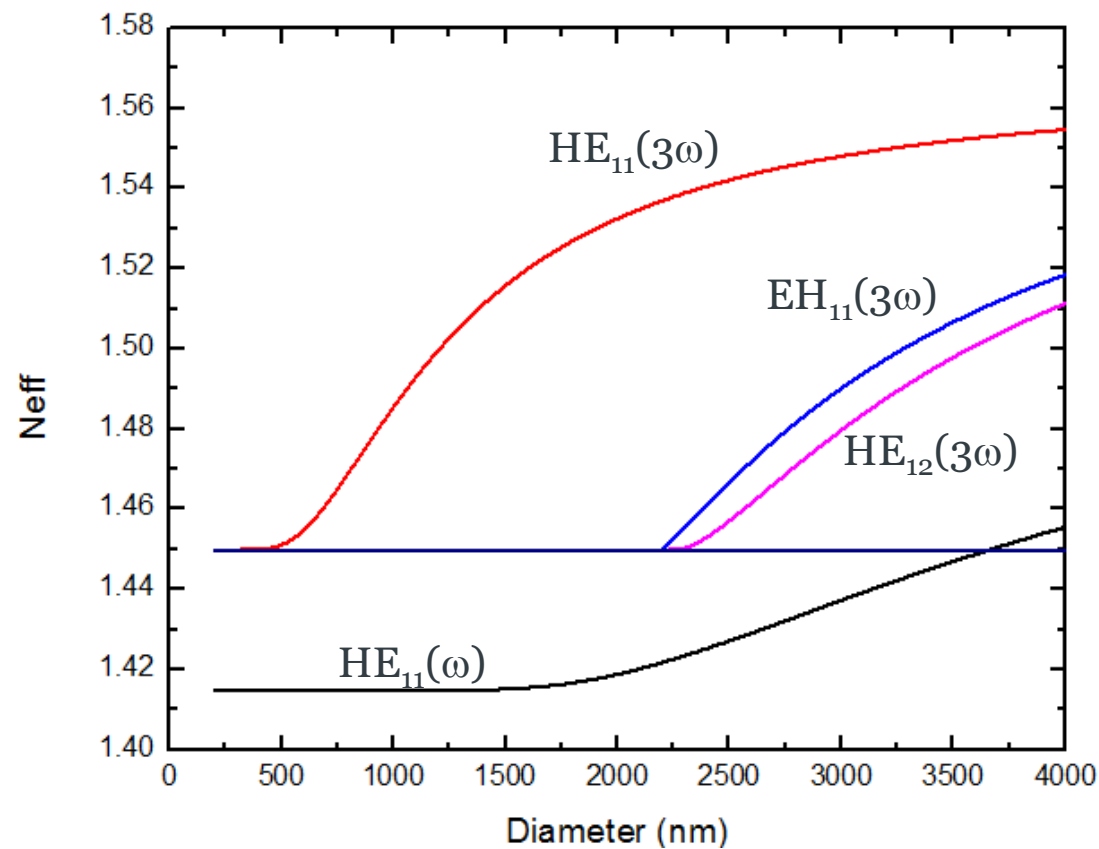
Conclusions

Fibres: Phase matching

$$\lambda_p = 1.06 \mu\text{m}; \lambda_s = 3.18 \mu\text{m}$$

Ge-doped silica fibre. [Ge]=60%

NA~0.52



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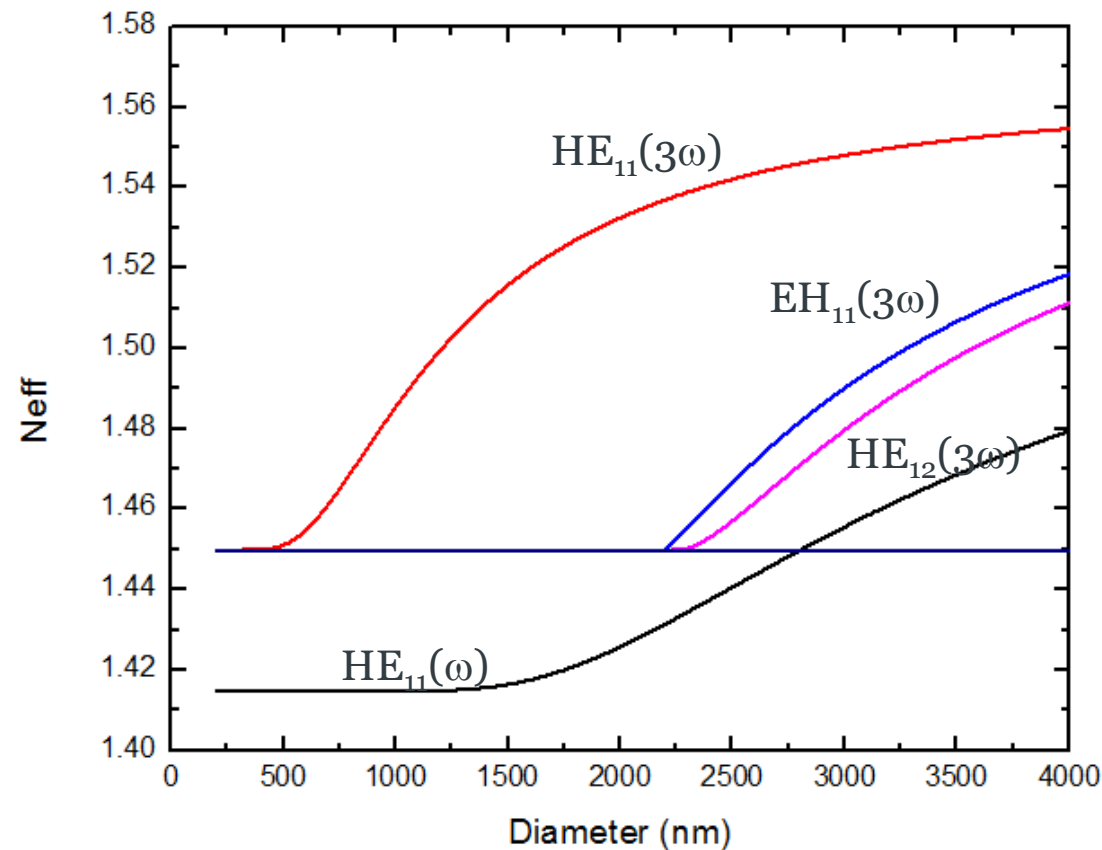
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Fibres: Phase matching

$$\lambda_p = 1.06 \mu\text{m}; \lambda_s = 3.18 \mu\text{m}$$

Ge-doped silica fibre. [Ge]=80%

NA~0.6



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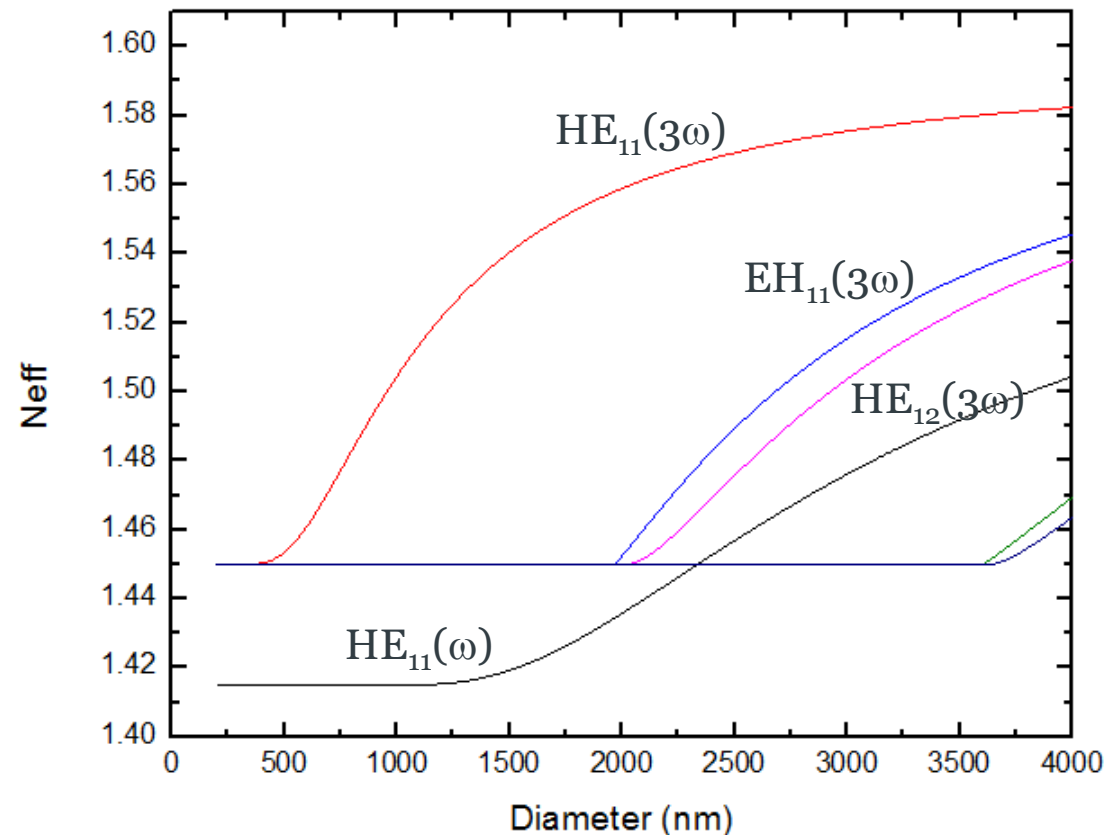
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Fibres: Phase matching

$$\lambda_p = 1.06 \mu\text{m}; \lambda_s = 3.18 \mu\text{m}$$

Ge-doped silica fibre. [Ge]=100%

NA~0.67



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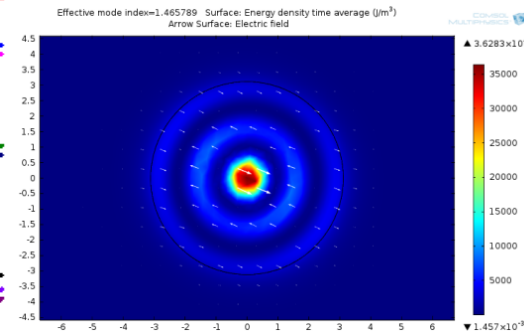
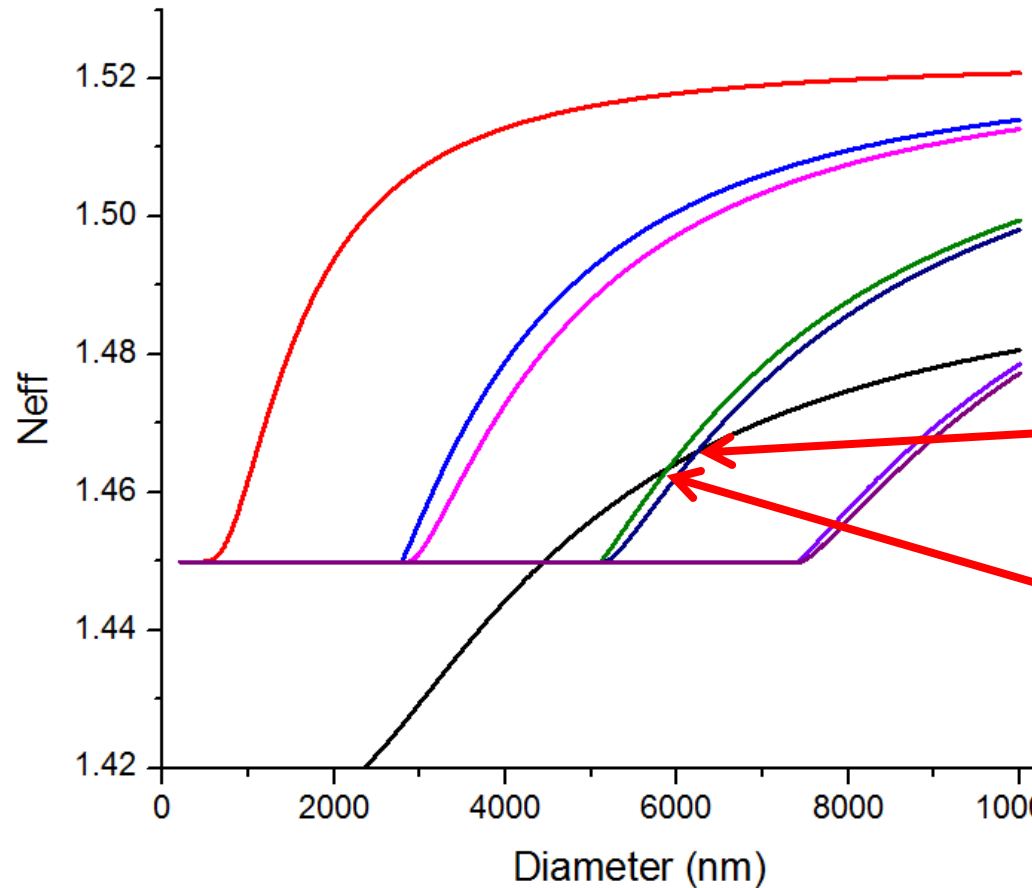
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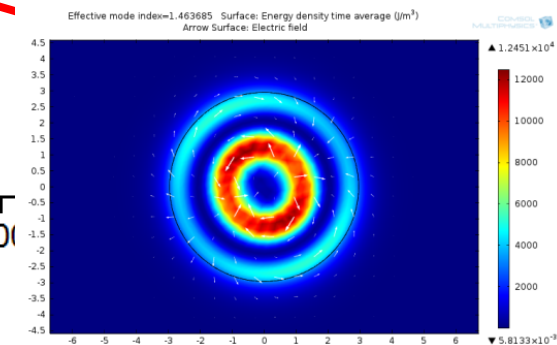
IR generation

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Fibres: Phase matching The Good News



6232.5 nm-1.4658



5911.5 nm-1.4636

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PM takes place at large core diameters

Nonlinearity

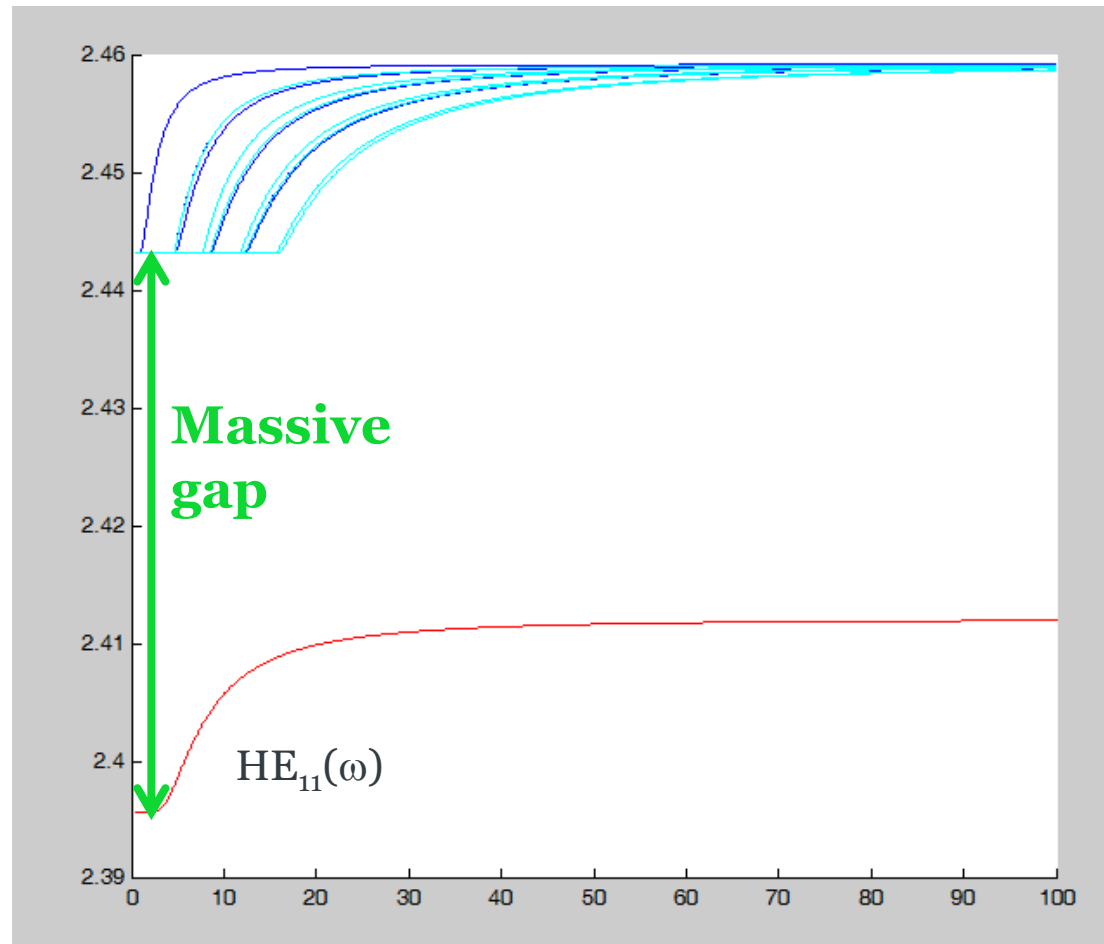
$$\gamma = \frac{2\pi}{\lambda} \frac{n_2}{A_{\text{eff}}}$$

Fiber Type	γ @1550nm
Standard SMF	1
Pure silica microwire	>100
Lead Silicate microwire (F2)	~1000
Bismuth Silicate microwire	>6000
Chalcogenide microwire	up to 100000

CHG fibres: Phase matching

$$\lambda_p = 1.06 \mu\text{m}; \lambda_s = 3.18 \mu\text{m}$$

$$\text{NA} = 0.28$$



In high n materials refractive index dispersion compensation is much more difficult

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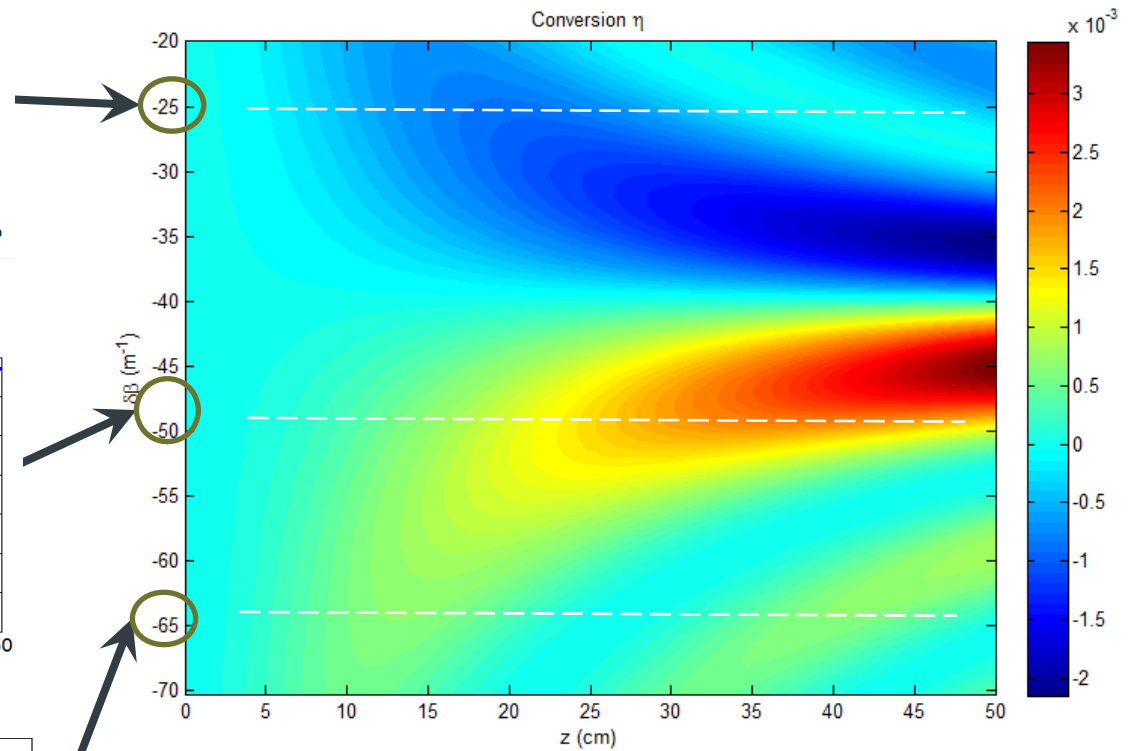
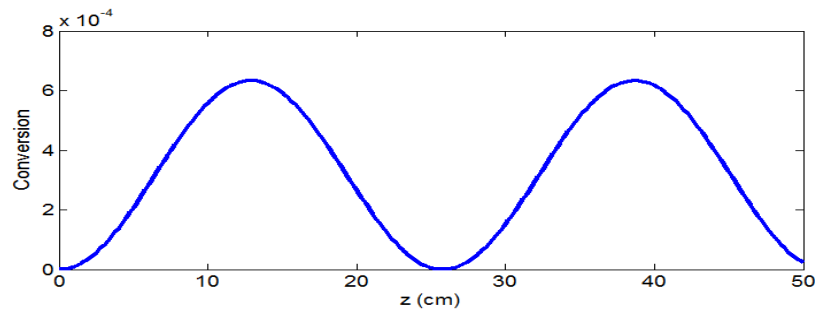
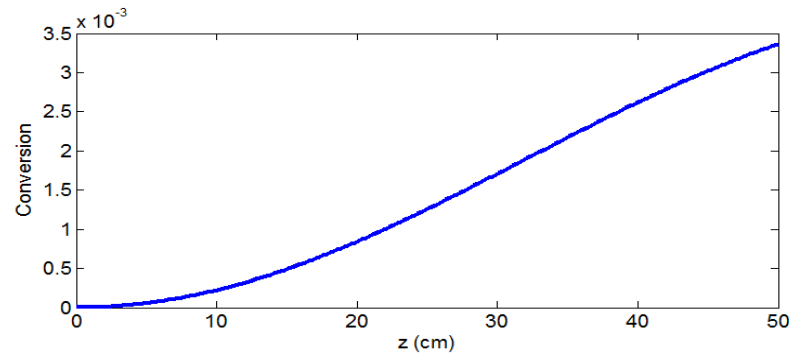
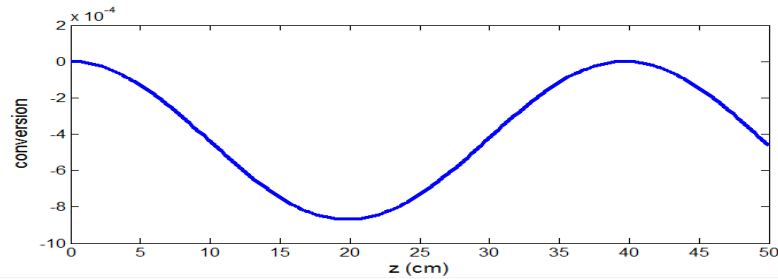
Conclusions

Fibres: detuning

$$P_s = 10\text{W}, P_p = 1\text{kW}$$



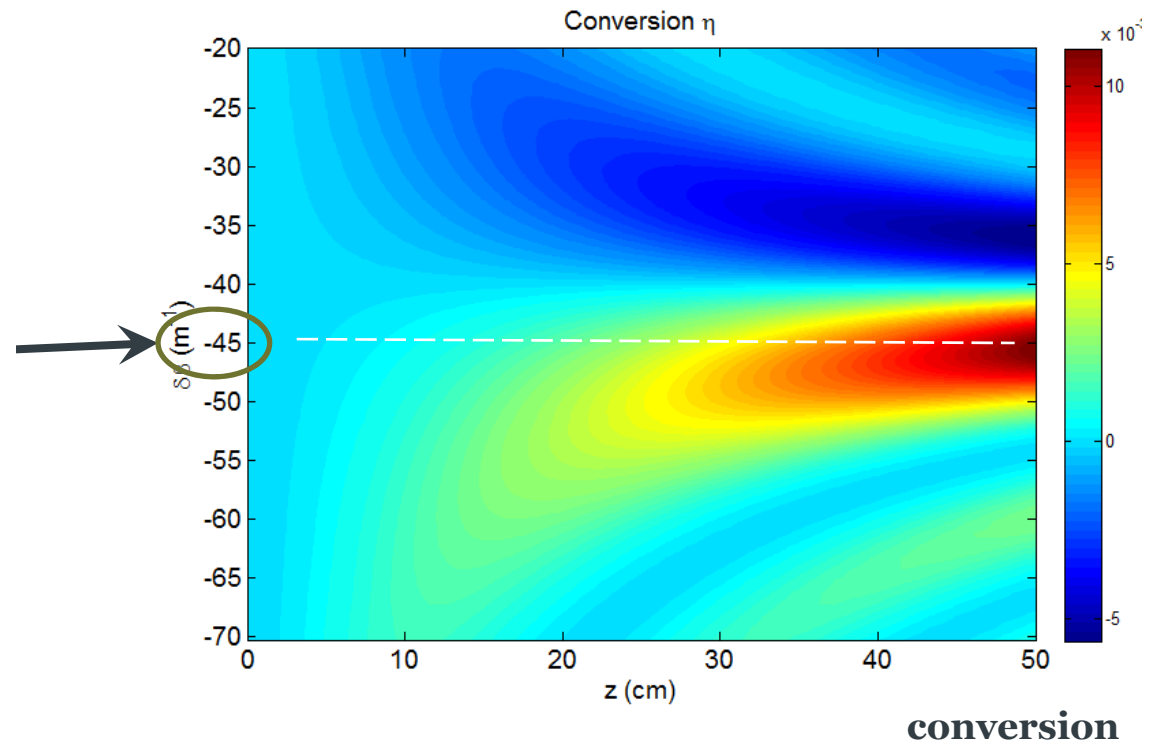
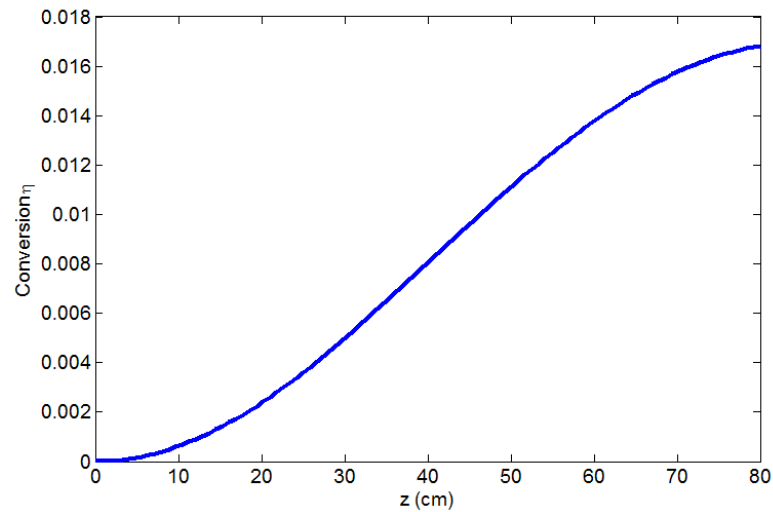
$$\eta = (P_{s-out} - P_{s-in}) / P_{p-in}$$



**conversion
efficiency**

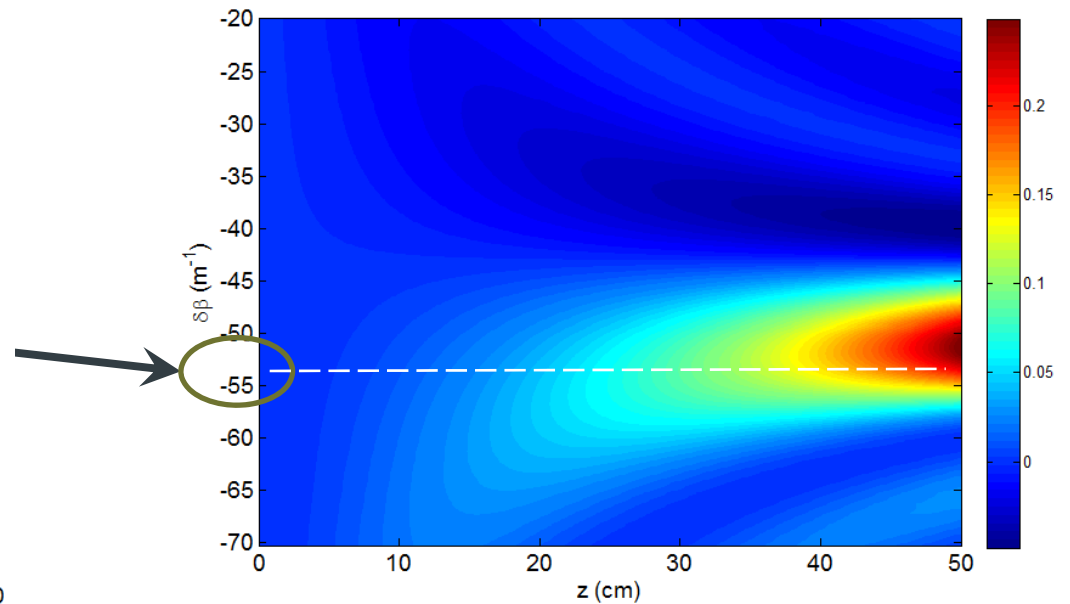
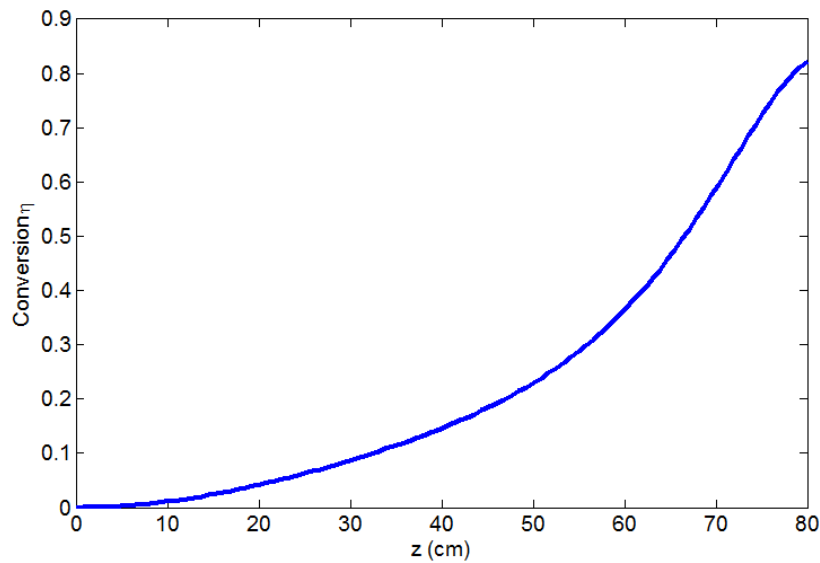
Fibres: detuning

$$P_s = 20\text{W}, P_p = 1\text{kW}$$



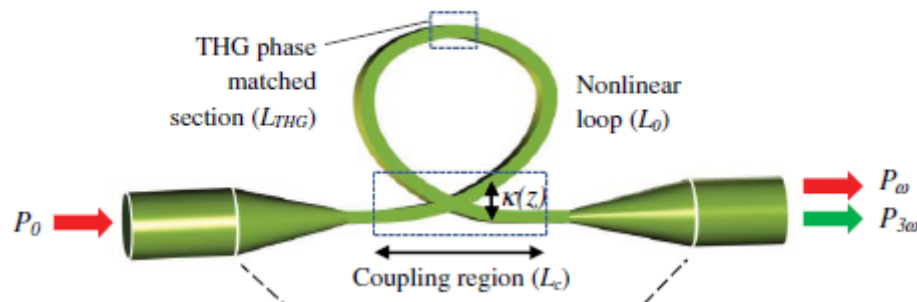
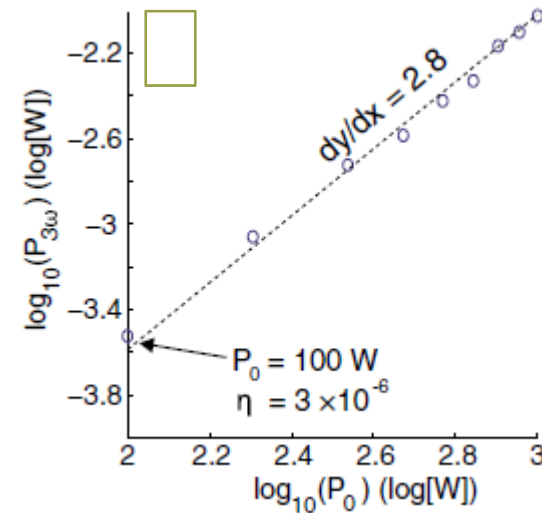
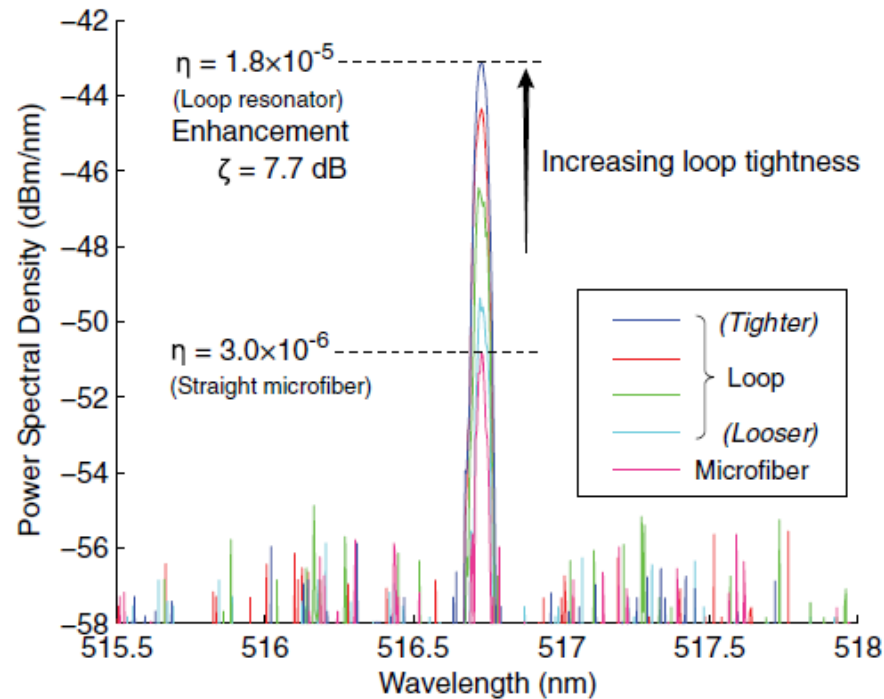
Fibres: detuning

$$P_s=100\text{W}, P_p=1\text{kW}$$



conversion

THG: resonant effects



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Conclusions

Silica has loss ,1dB/mm in the UV (200nm) and IR (up to 4.5 μ m)

Fibres and tapers can be used to generate light in the UV or IR

Up-conversion (THG) \rightarrow UV generation

Down-Conversion (TPG) \rightarrow IR generation

Efficiencies as high as 90% have been predicted for phase-matched optimised diameters, detuning ad length.

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Rand Ismaeel

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Thank you
questions?